



Fabrication of amorphous and crystalline mirror coatings for reaching the thermal noise requirements 2G+ and 3G detectors

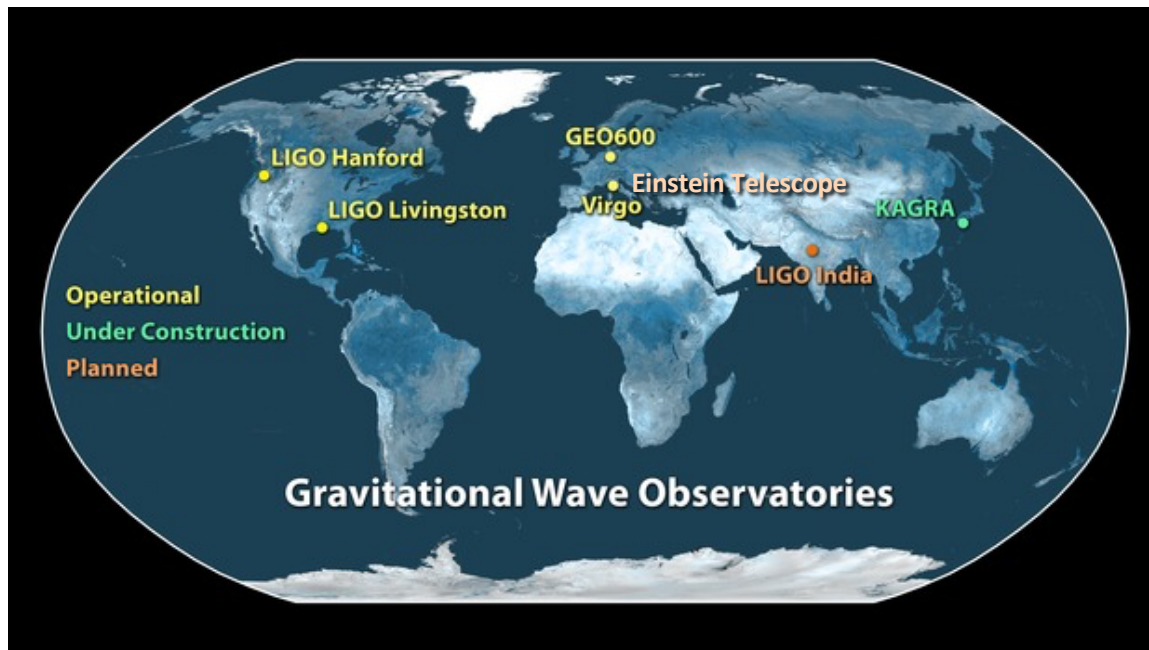
Stuart Reid
Department of Biomedical Engineering,
University of Strathclyde

on behalf of Glasgow, Strathclyde, UWS and
Stanford groups and industrial partners

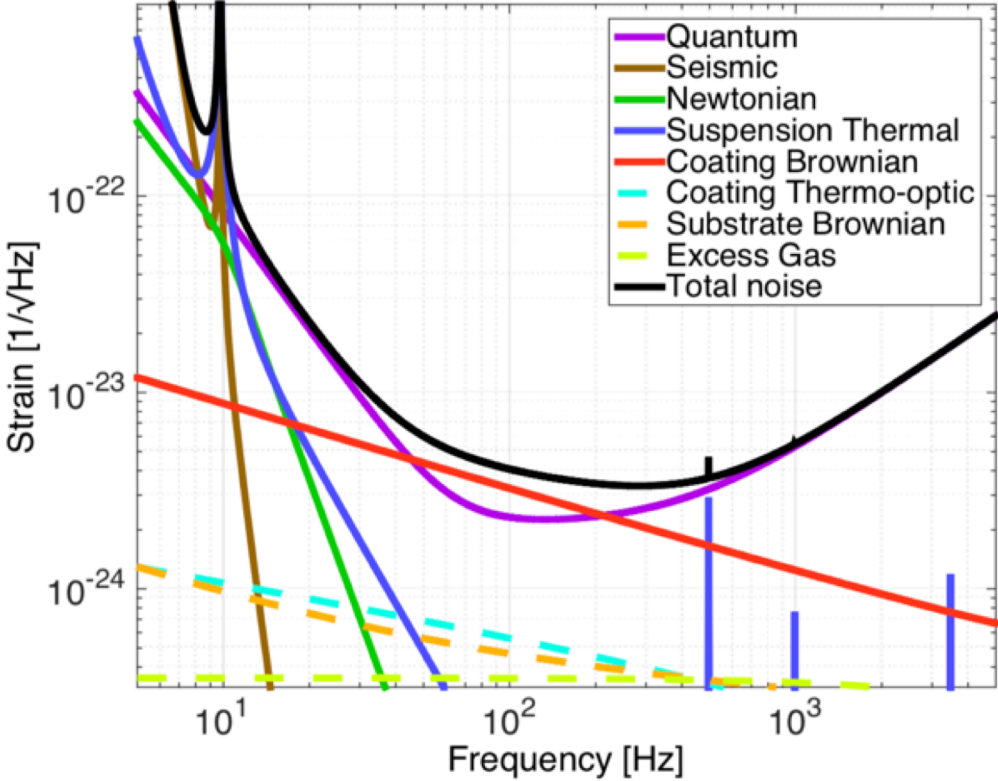
Long-term collaborations in GW networks



Towards the future GW network

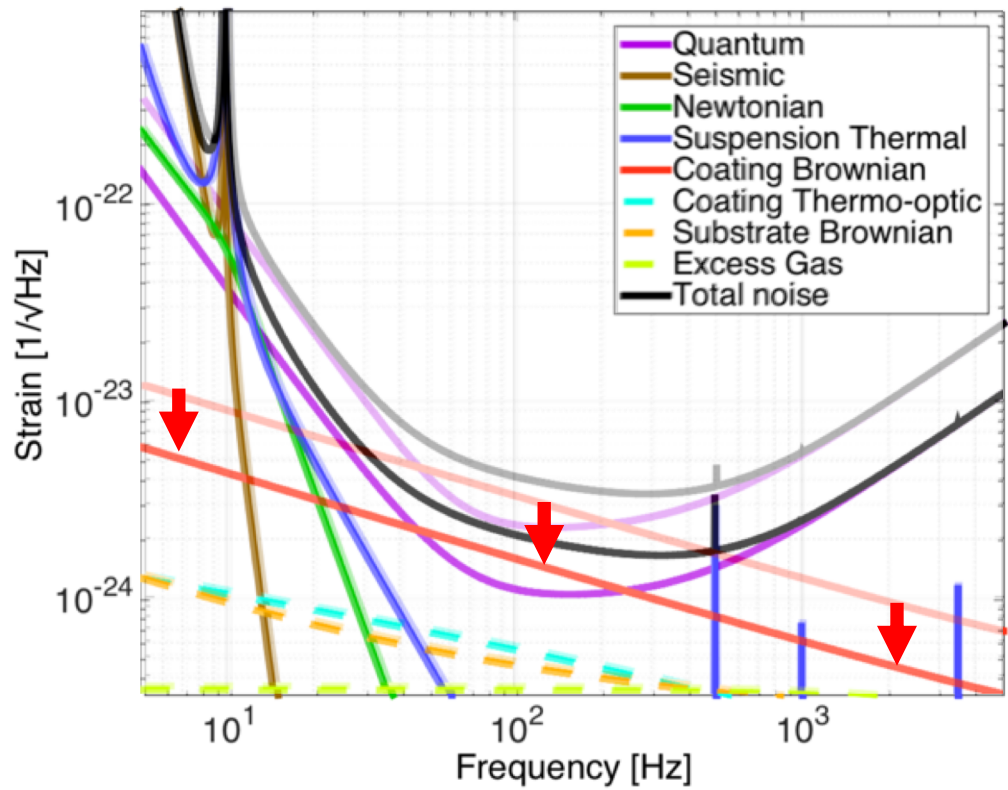


Focus largely on A+



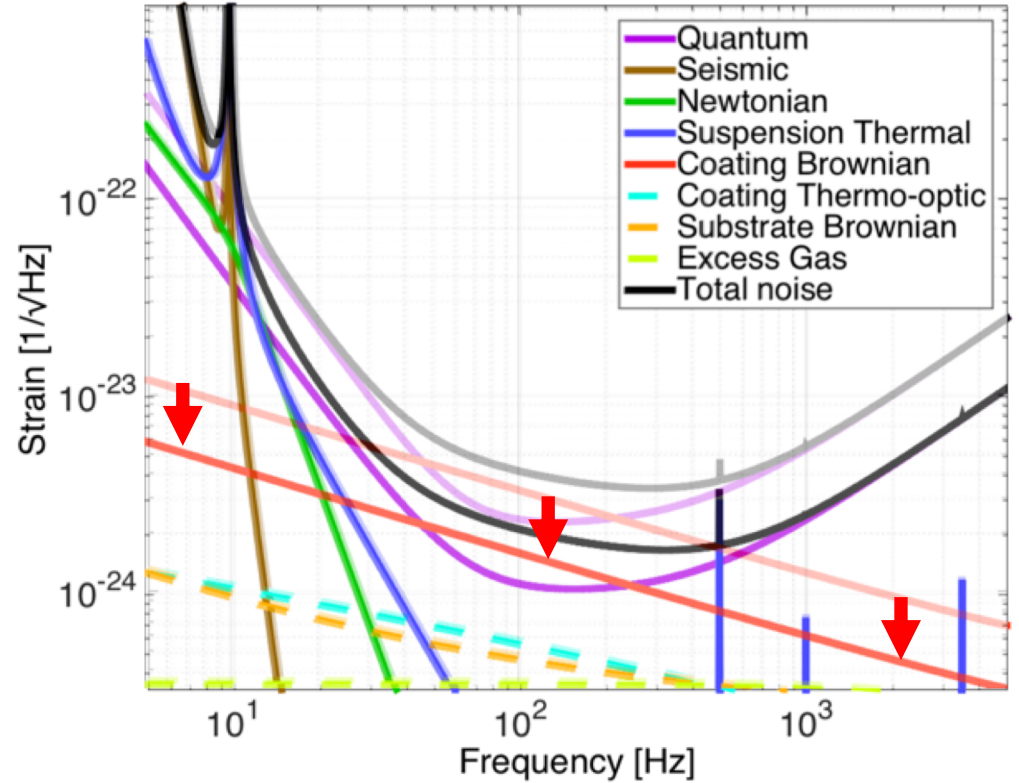
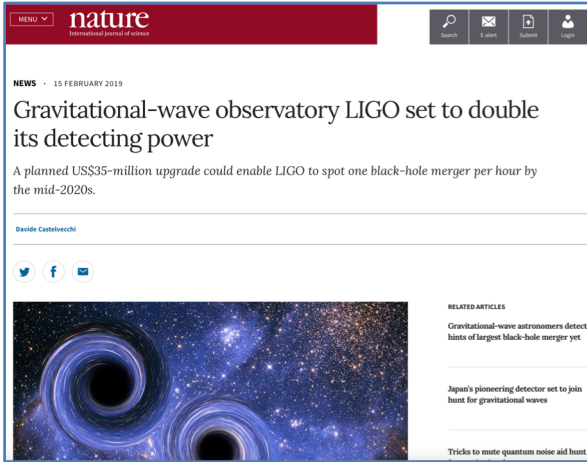
LIGO India will be constructed as an A+ instrument
Factor 4 reduction in coating loss (factor 2 in strain noise) required by 2020!

Focus largely on A+



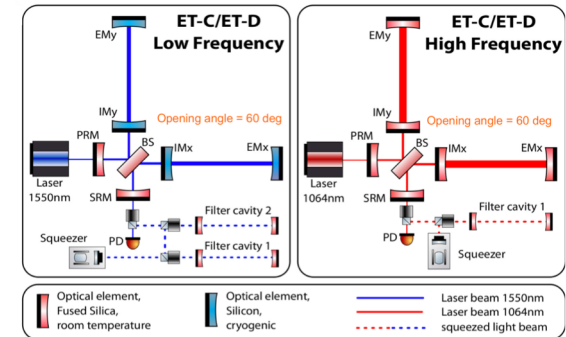
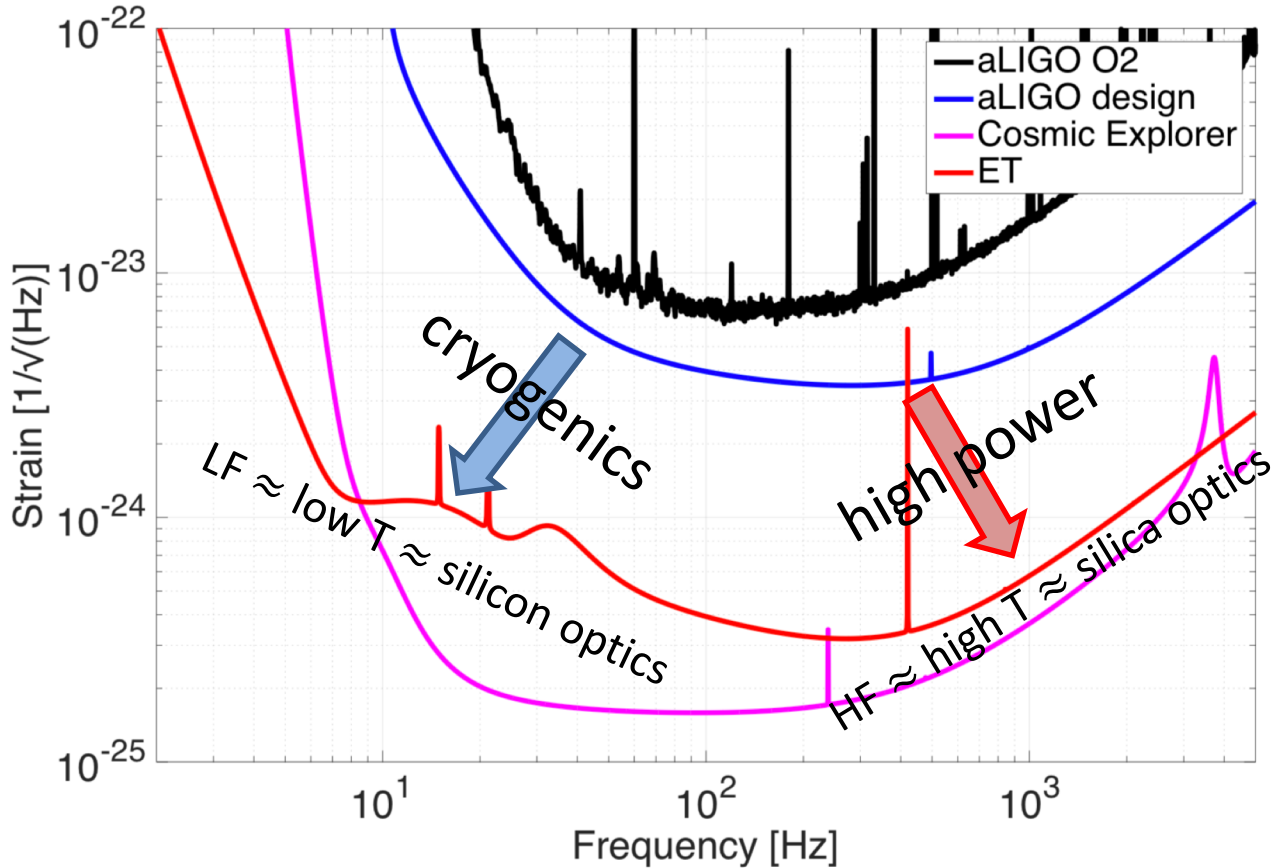
LIGO India will be constructed as an A+ instrument
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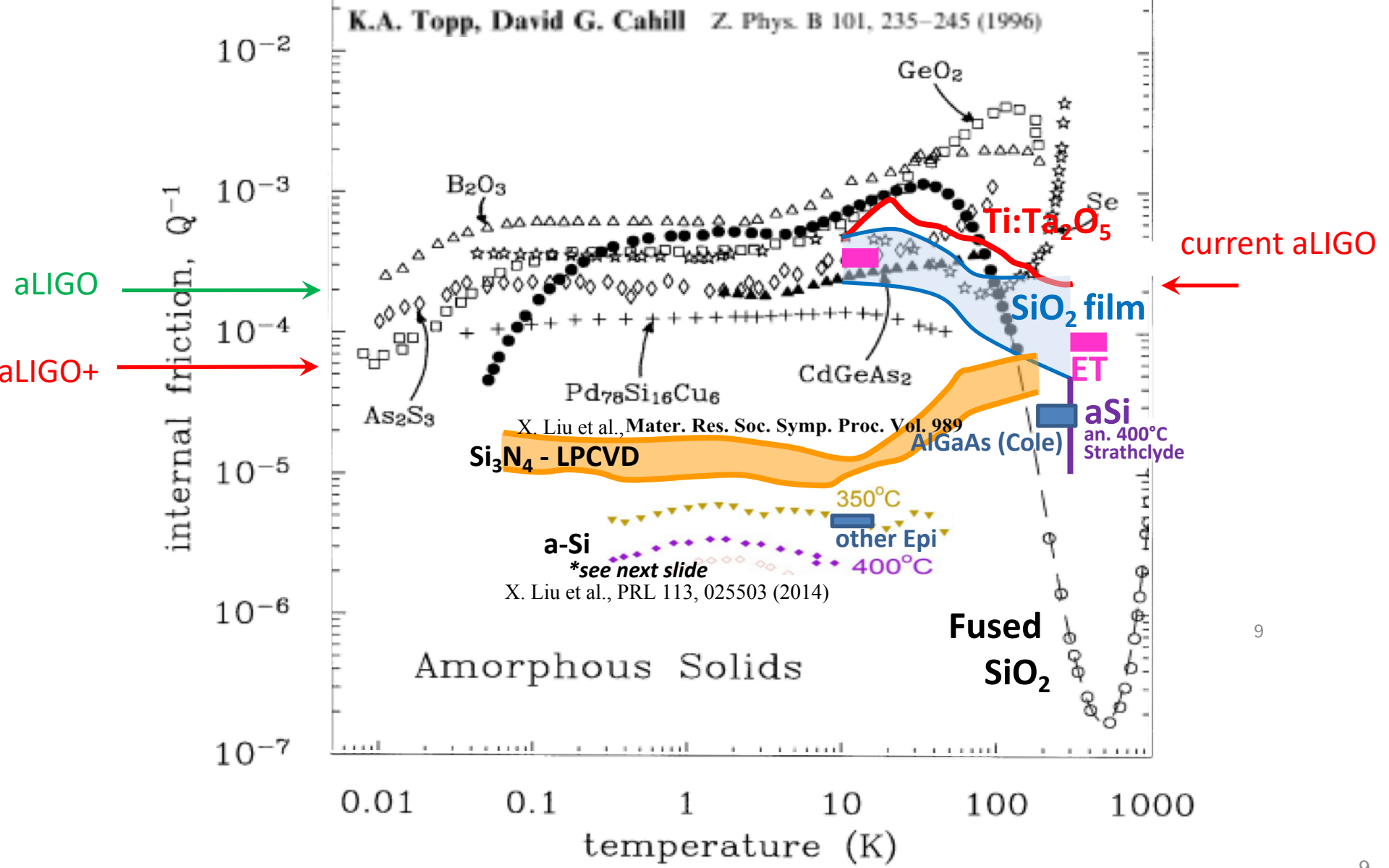
A+ (funding announced Feb 2019)



Factor 4 reduction in coating loss (factor 2 in strain noise) ~2020!

3G – xylophone concept

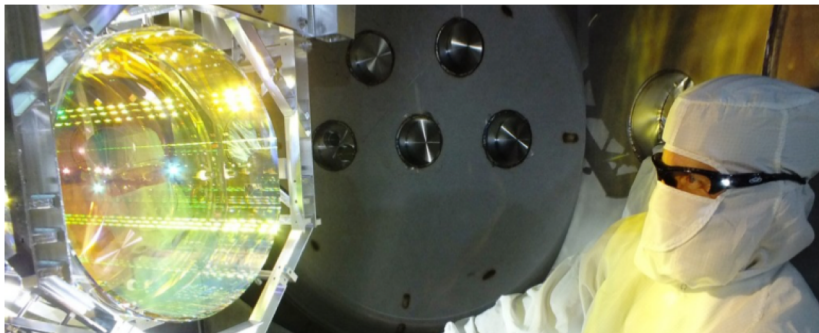




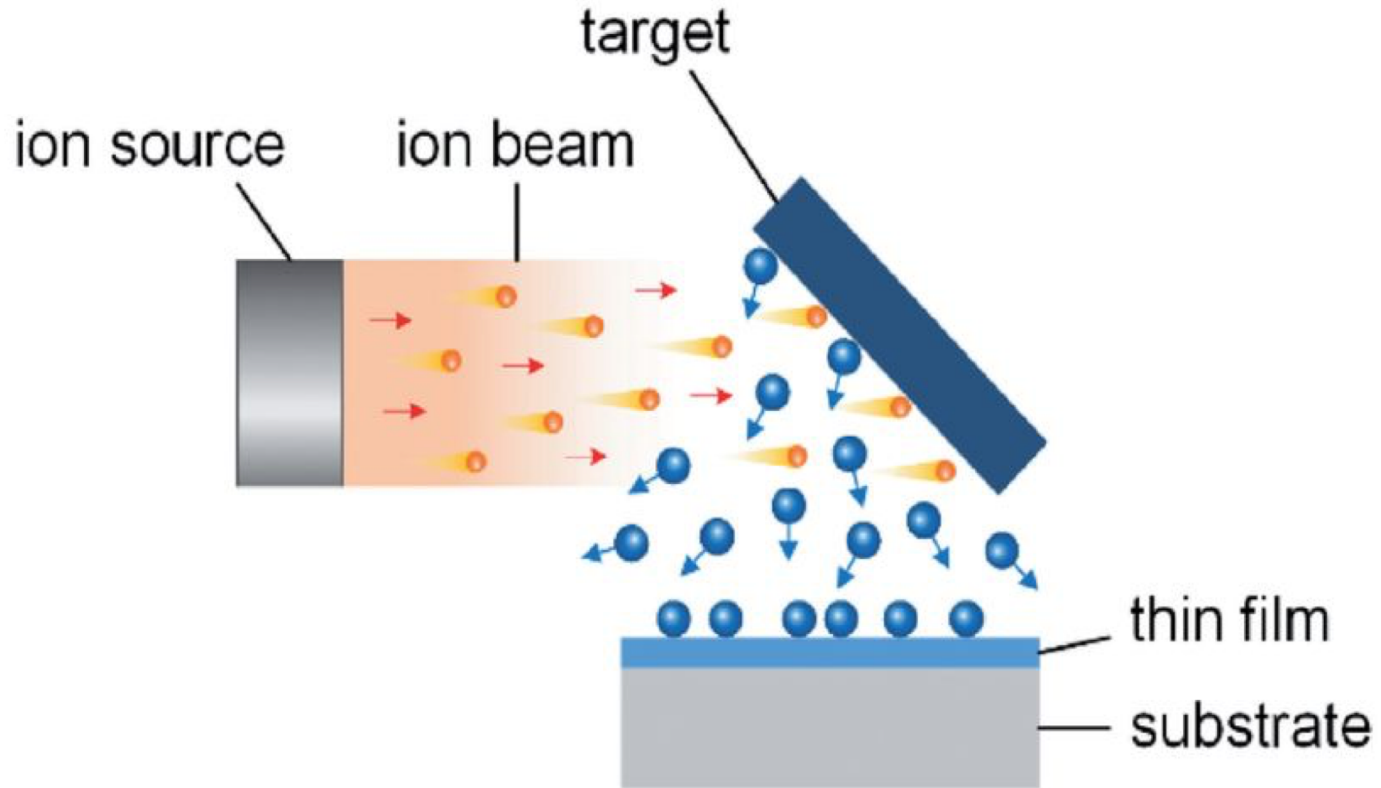
Advanced LIGO – mirror requirements

Requirements for aLIGO at 1064 nm:

- Absorption <0.5 ppm
- Scatter <2 ppm
- ITM transmission: $(5 \pm 0.25) \times 10^{-3}$
- ETM transmission: <10 ppm
- Mechanical loss: 3×10^{-5} Goal (1×10^{-4})
- Uniformity +/- 0.5% over 34 cm



Ion beam deposition (IBD)



Strategy for 3G – all (sensible) options open!

Standard IBD – new/modified materials, alternative coating designs (e.g. mixed material, nanolayers,...), optimised post-annealing.

Modified IBD – extend dep parameter space (e.g. ion energy, dep rate, gas/materials), inclusion of assist processes?

MBE – switch to crystalline mirror coatings

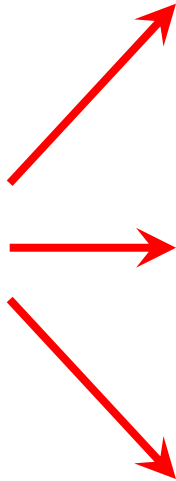
other?!

Reduced TN
mirror coatings
for + and 3G

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graph LR; A[Reduced TN mirror coatings for + and 3G] --> B[Standard IBD]; A --> C[Modified IBD]; A --> D[MBE]; A --> E[other?!];
```

Strategy for 3G – all (sensible) options open!

Reduced TN
mirror coatings
for + and 3G



Standard IBD – new/modified materials, alternative coating designs (e.g. mixed material, nanolayers,...), optimised post-annealing.

Benefit: manufacture of mirrors unchanged, geometry/optical spec. ✓
Risk: two decades of research did not achieve factor 4 reduction in ϕ ...

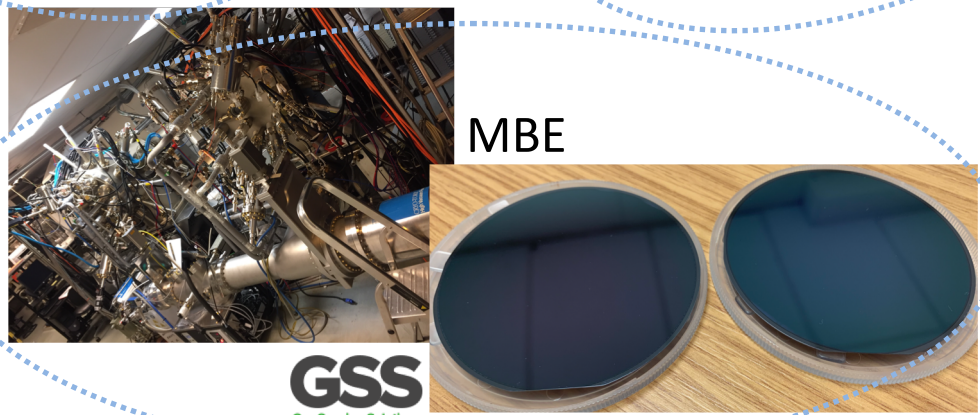
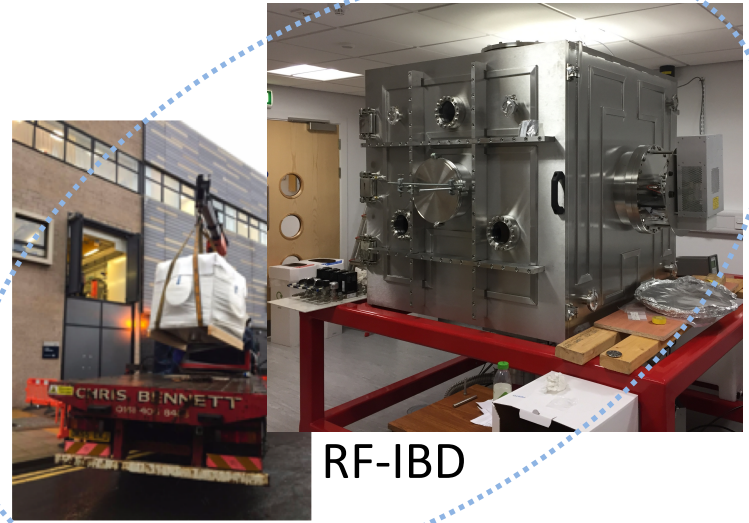
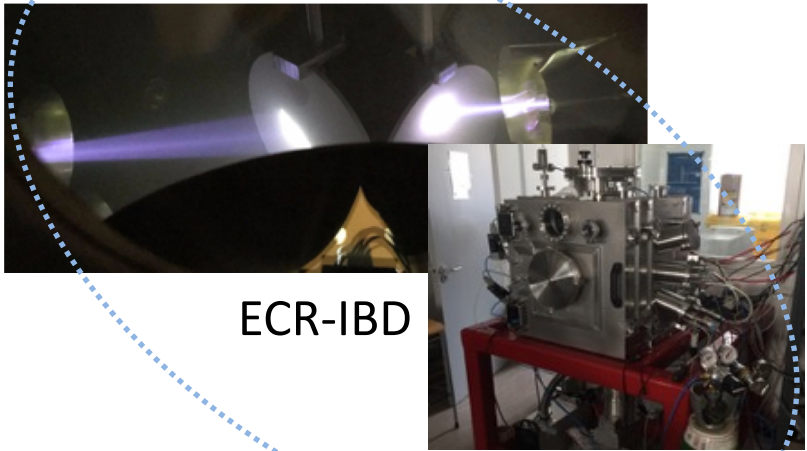
Modified IBD – extend dep parameter space (e.g. ion energy, dep rate, gas/materials), inclusion of assist processes?

Benefit: manufacture of mirrors similar, scalability prob OK
Risk: no major industrial driver to support this approach – we need to do it!

MBE – switch to crystalline mirror coatings

Benefit: can satisfy optical and mechanical requirements easily
Risk: needs to be grown on lattice-matched substrate or transferred, area requires significant scaling (again industrial drivers unclear and are also commercially sensitive)

Coating technologies: ECR/RF IBD and MBE

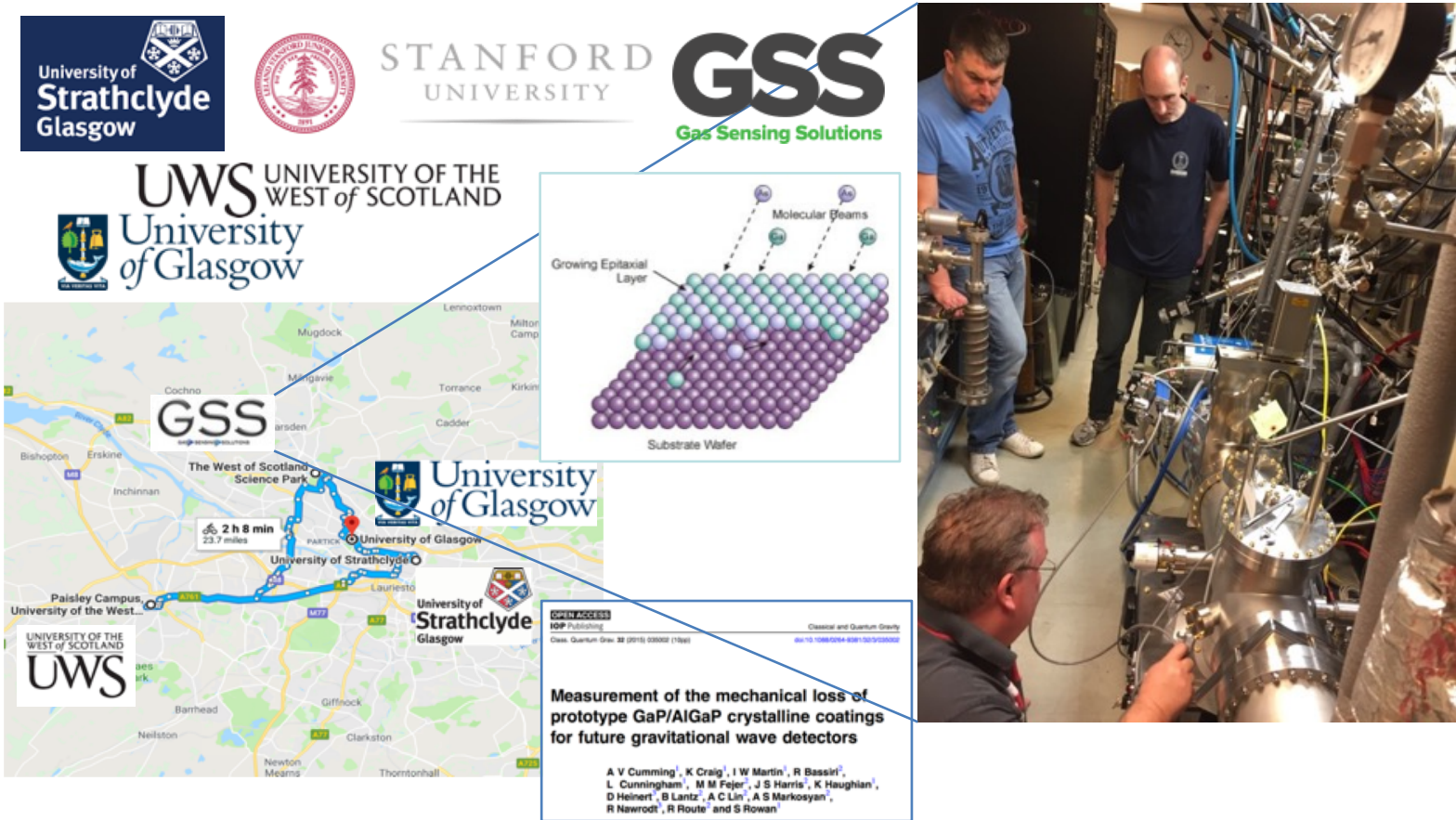


Coating technologies: ECR-IBD, RF-IBD and MBE



MBE – located in Gas Sensing Solutions

Crystalline coatings – possible 3rd generation solution:
P growths underway



University of Strathclyde Glasgow

STANFORD UNIVERSITY

GSS
Gas Sensing Solutions

UWS UNIVERSITY OF THE WEST OF SCOTLAND
University of Glasgow

GSS
The West of Scotland Science Park
2 h 8 min
23.7 miles

University of Glasgow

University of Strathclyde Glasgow

University of Strathclyde Glasgow

UWS

Measurement of the mechanical loss of prototype GaP/AlGaP crystalline coatings for future gravitational wave detectors

A V Cumming¹, K Craig¹, I W Martin¹, R Bassiri², L Cunningham¹, M M Fejer², J S Harris¹, K Haughlan¹, D Helmer¹, B Lantz¹, A C Lin¹, A S Markosyan¹, R Nawrodt¹, R Route¹ and S Rowan¹

OPEN ACCESS
IOP Publishing
Classical and Quantum Gravity
10.1088/0264-4398/35/12/125002

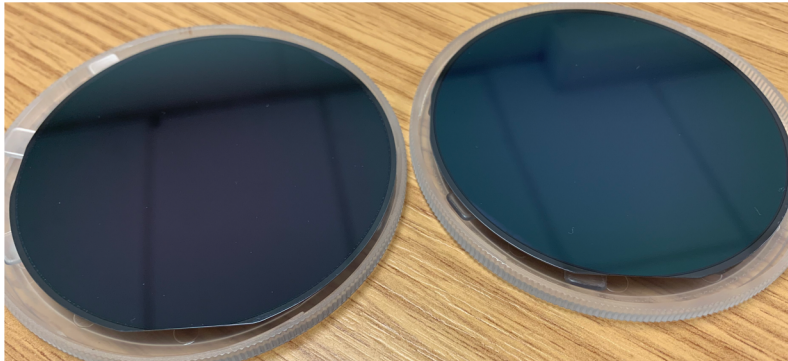
MBE – located in Gas Sensing Solutions

Crystalline coatings – possible 3rd generation solution:

P growths underway

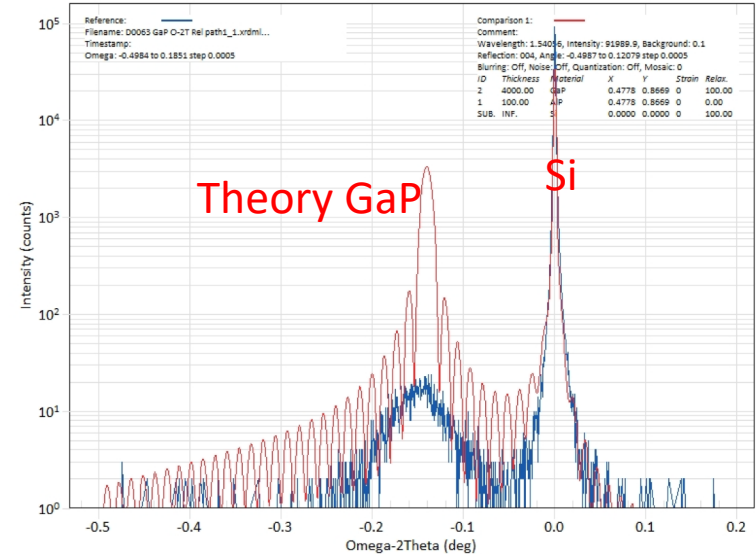


STANFORD UNIVERSITY



300nm GaP coatings on Si

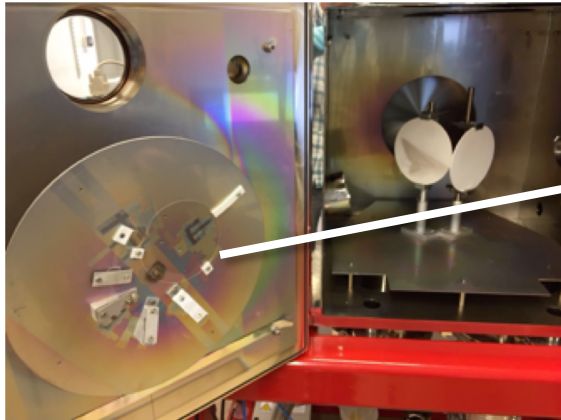
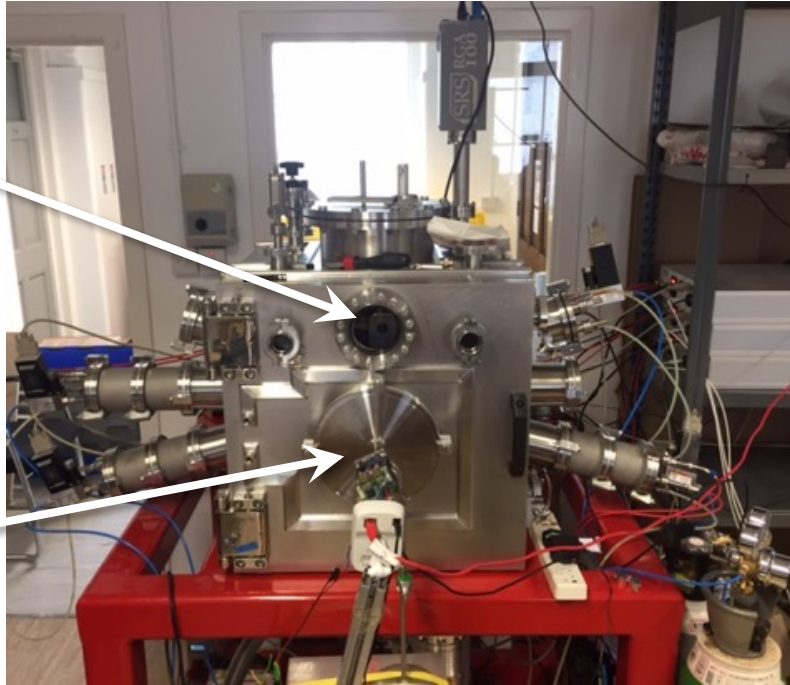
XRD



measured GaP

ECR plans

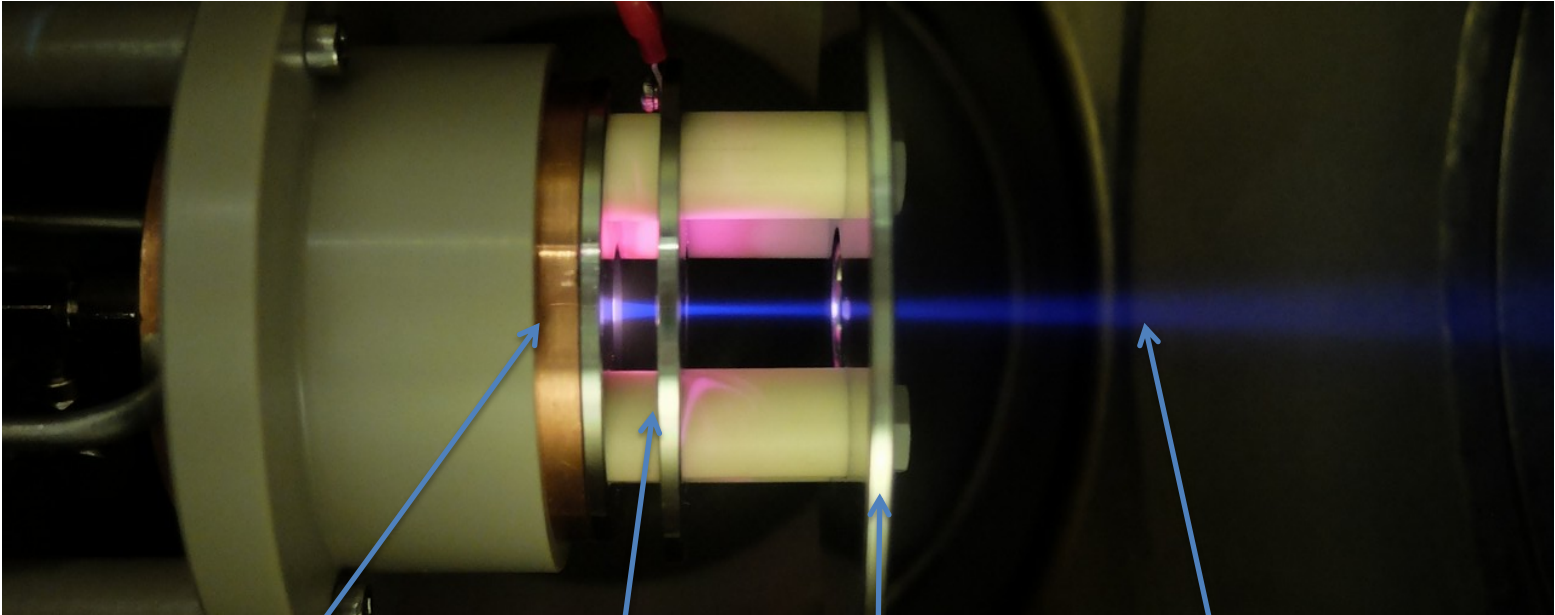
4 ion sources (soon 6 + 2 ECR plasma cavities) - independently controlled (LabView)



rotational staging – 14"

0.6 x 0.6 x 0.6 m chamber

Development of ECR-IBD



ECR plasma cavity
(microwave)

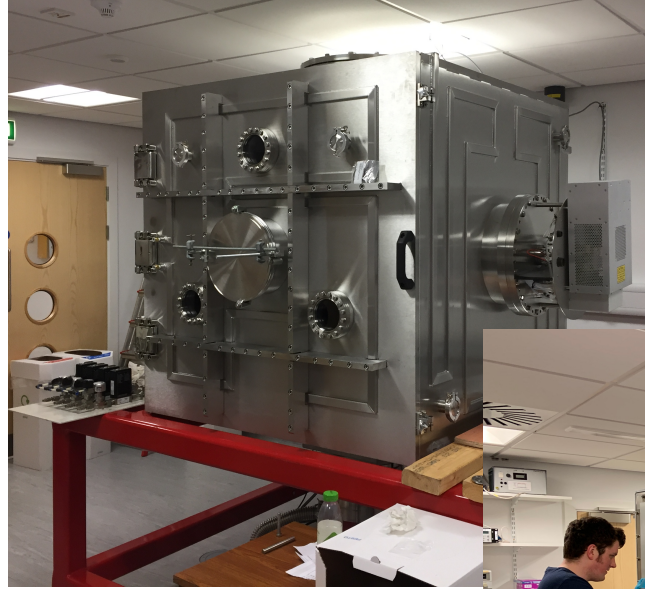
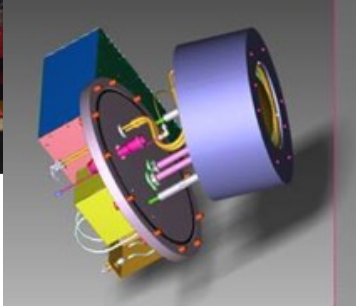
focus

ground

Divergent Ar ion beam

RF-IBD plans

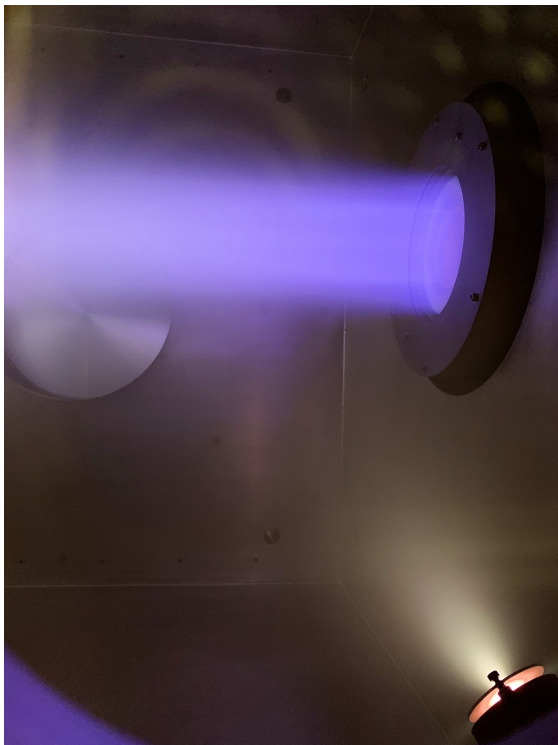
1.2 x 1.2 x 1.2 m chamber



Industry standard 16" RF ion source (Veeco – Spector equivalent)

Any process developed in this system should be easily transferrable to e.g. LMA Grand Coater

RF-IBD plans

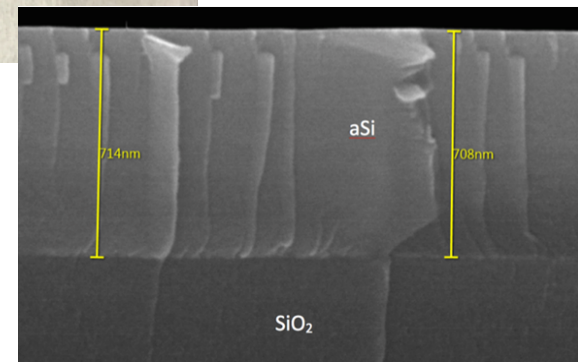
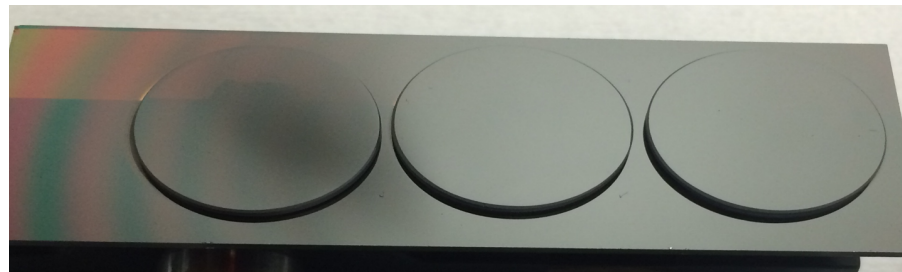
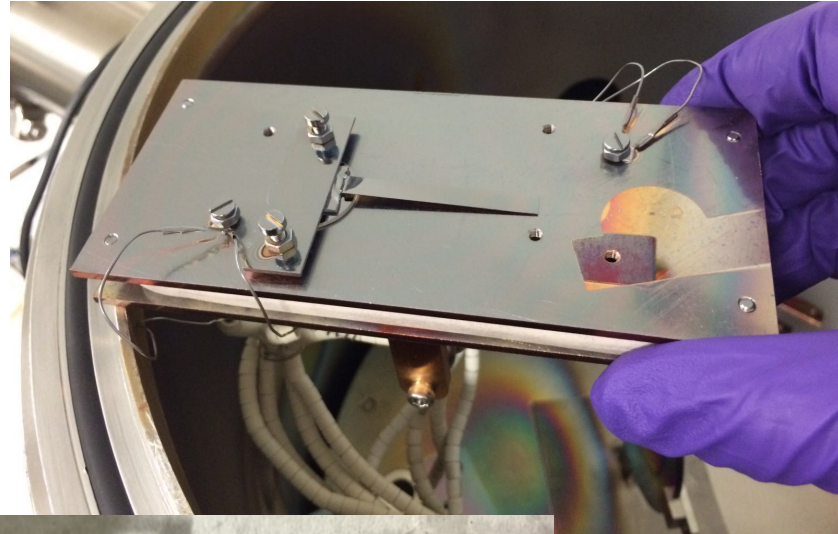


March 2019 first RF-ICP coating runs – TiO_2

Amorphous silicon

Copper mounting plate holds samples during deposition:

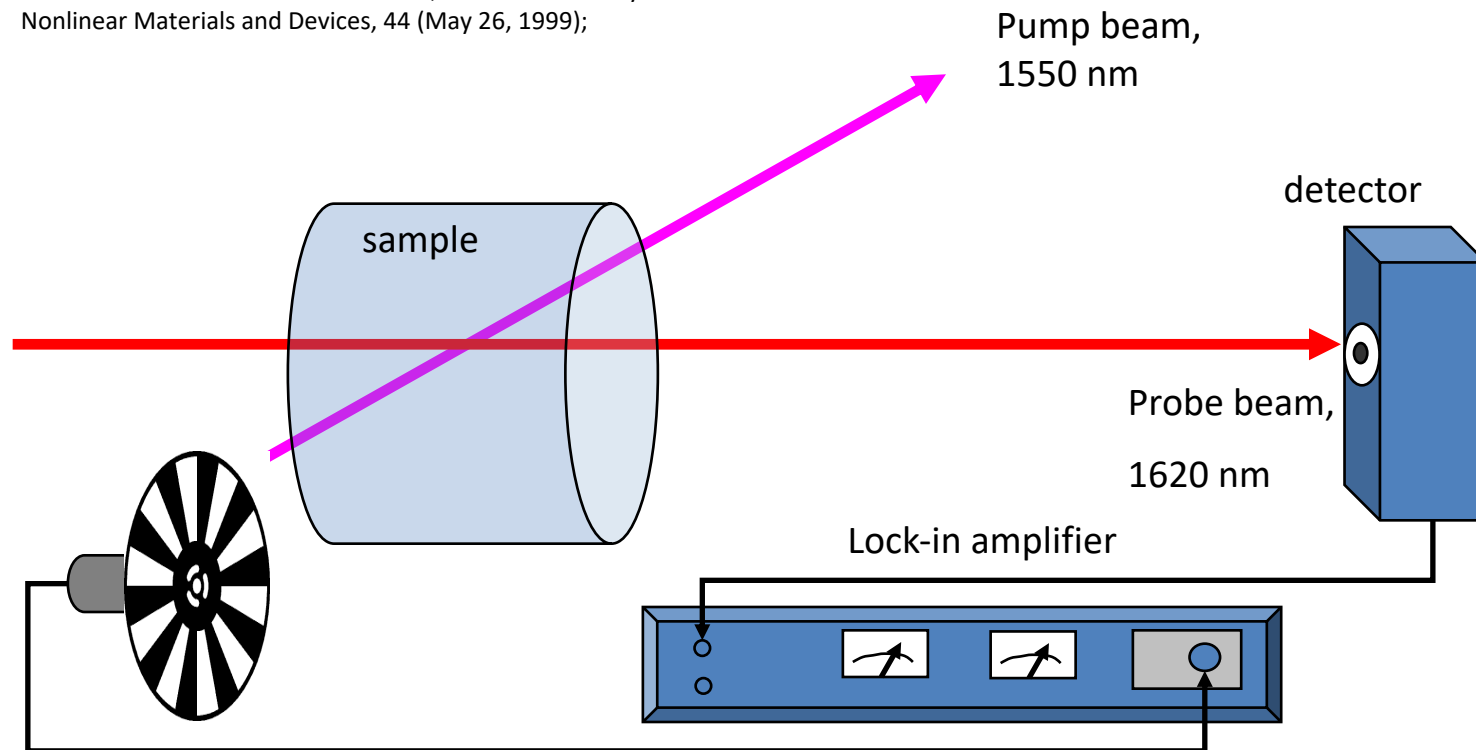
- SiO_2 cantilevers (mechanical loss)
- SiO_2 witness samples (optical studies)



Absorption measurements - Glasgow

Photo-thermal commonpath interferometry (PCI)

A. Alexandrovski et al. *Proc. SPIE* 3610, Laser Material Crystal Growth and Nonlinear Materials and Devices, 44 (May 26, 1999);



Absorption measurements - Glasgow

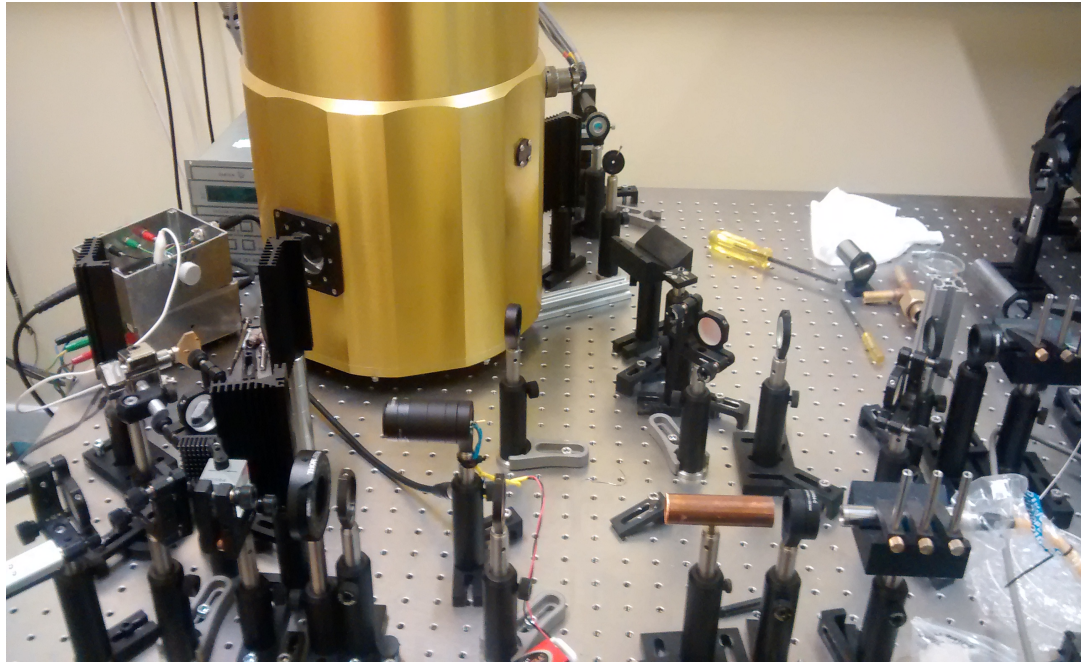
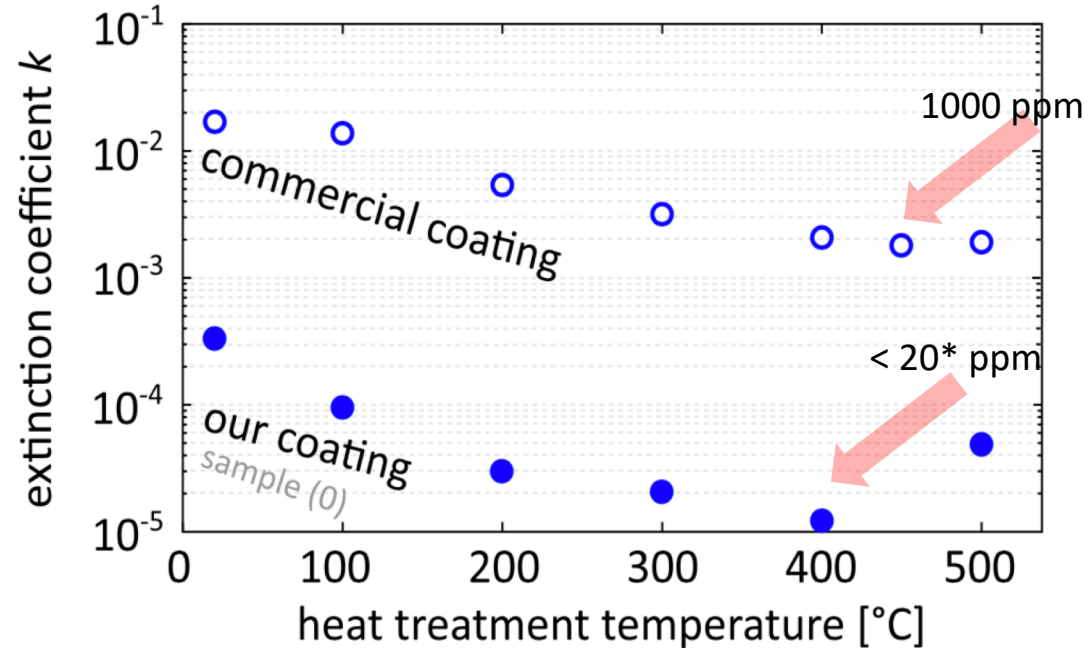


Figure 5 - photothermal absorption set up in UoG, capable of measuring ppm-level absorption in optical coatings

aSi Absorption – 1550nm



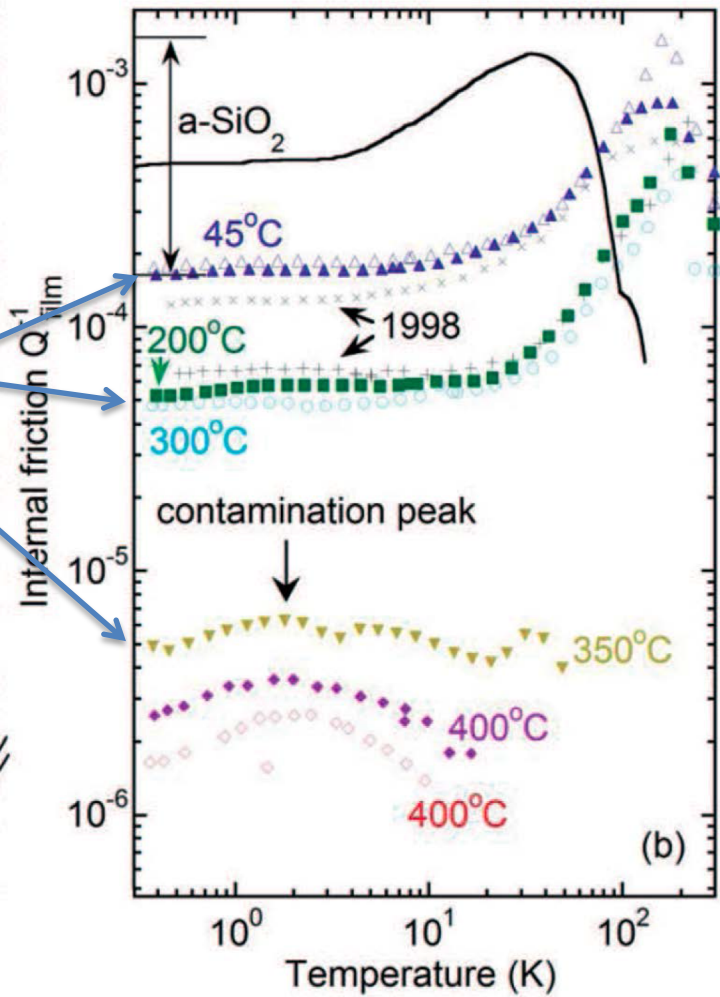
- 1550 nm
- Absorption significantly lower than for ATF coatings
- Refractive index ~ 3.4 from transmission measurements

* Measurements limited by absorption of substrate

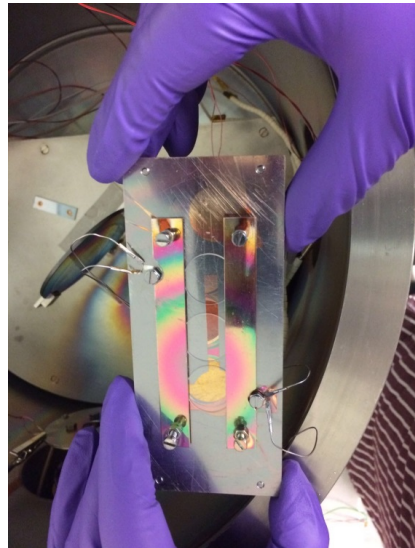
Other attractive solutions – elevated T dep.

- Significant interest in “ideal glass” structure
- Heated deposition reduces mechanical loss much further than post-heat treatment alone.
- $\sim 10^{-4}$ vs $\sim 10^{-6}$
- Surface mobility during deposition:
 - sound velocity approaches asymptote
 - distribution of bond angles narrows
 - density increasing
 - Heat capacity approaches bulk silicon value
- Open question – similar benefits for IBS?

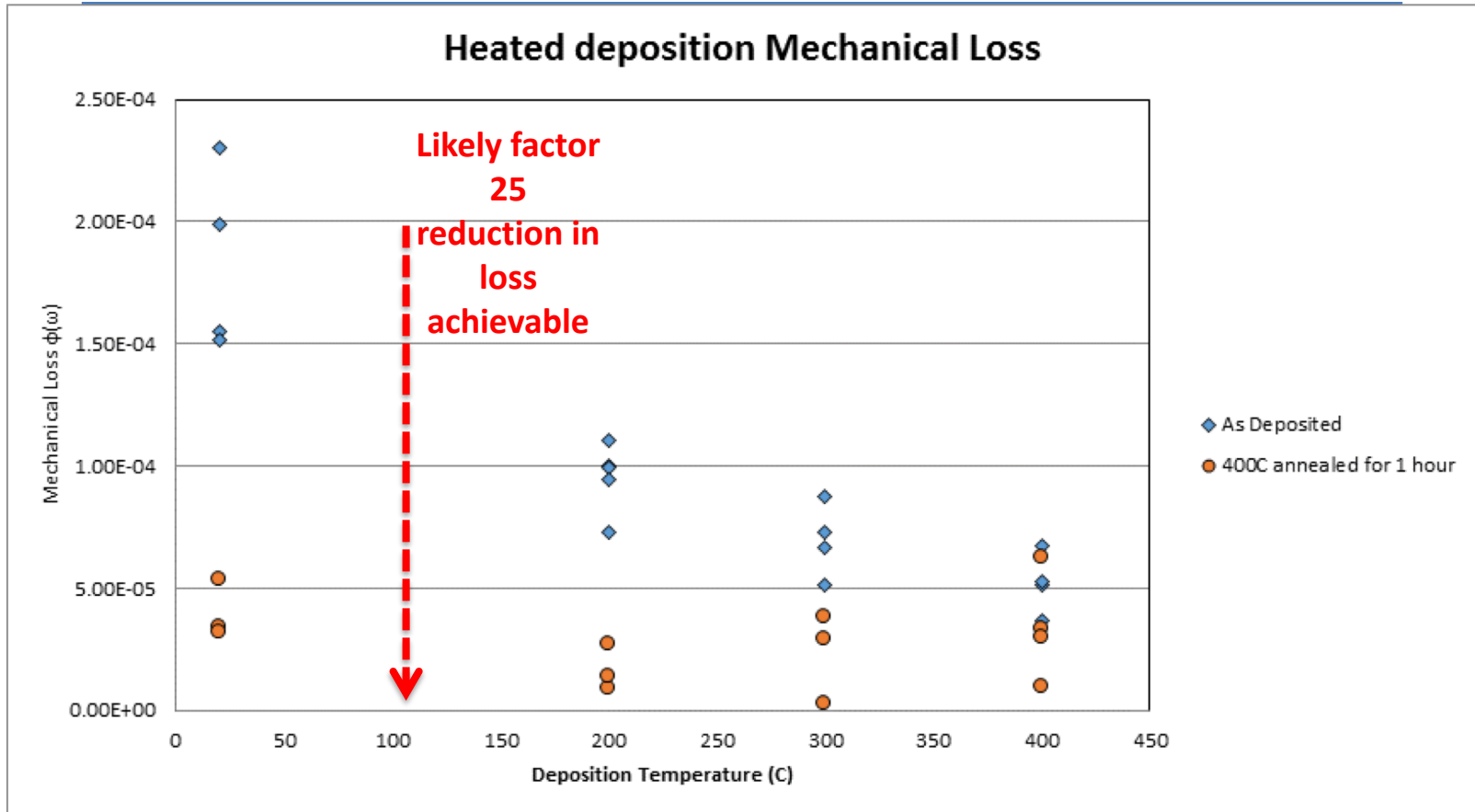
annealed 350C
deposited 350C



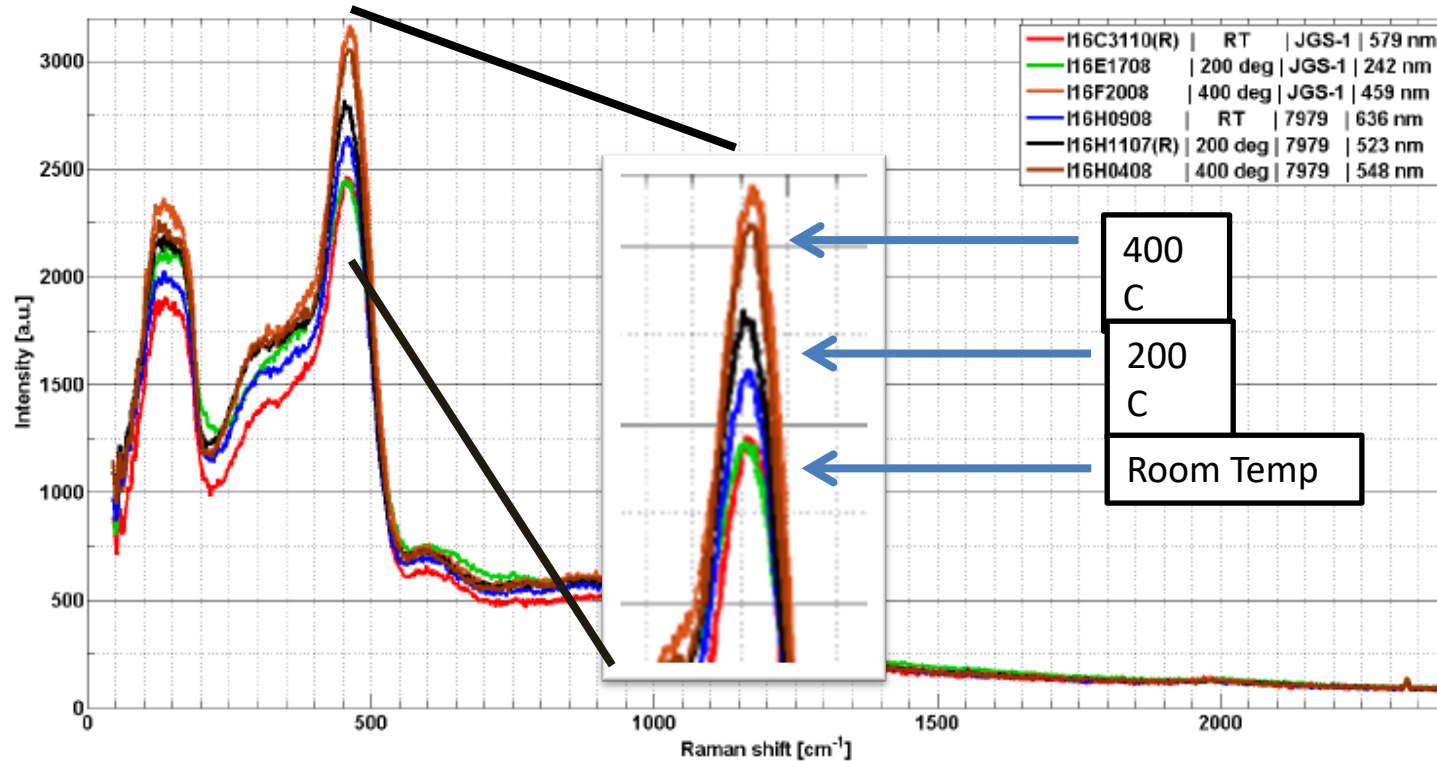
High-temperature deposition



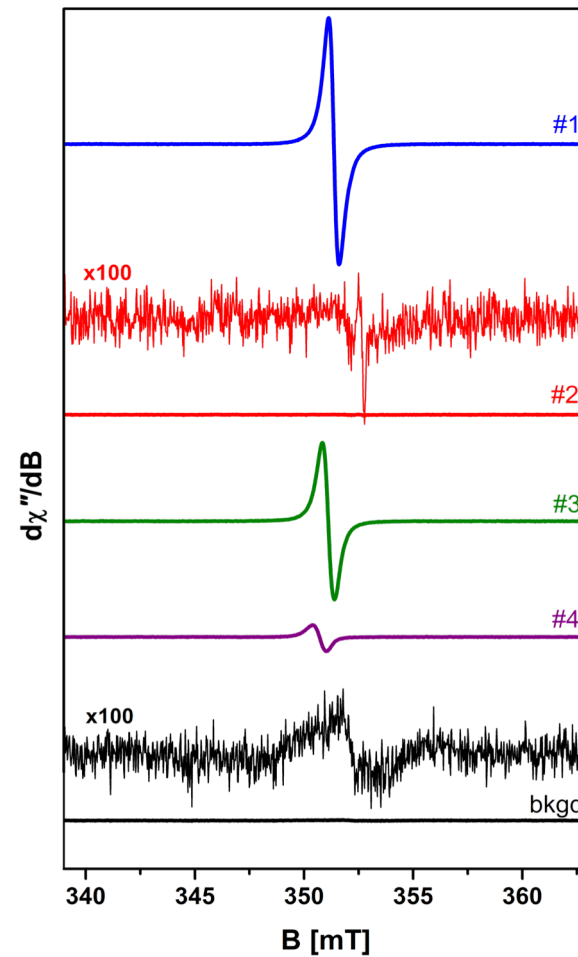
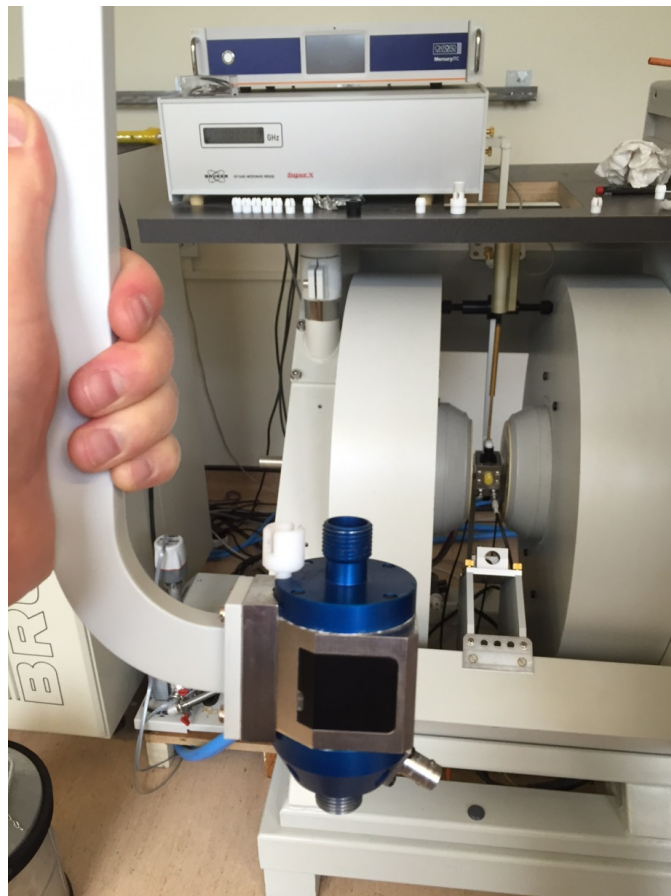
aSi Heated deposition losses



Characterisation – Raman



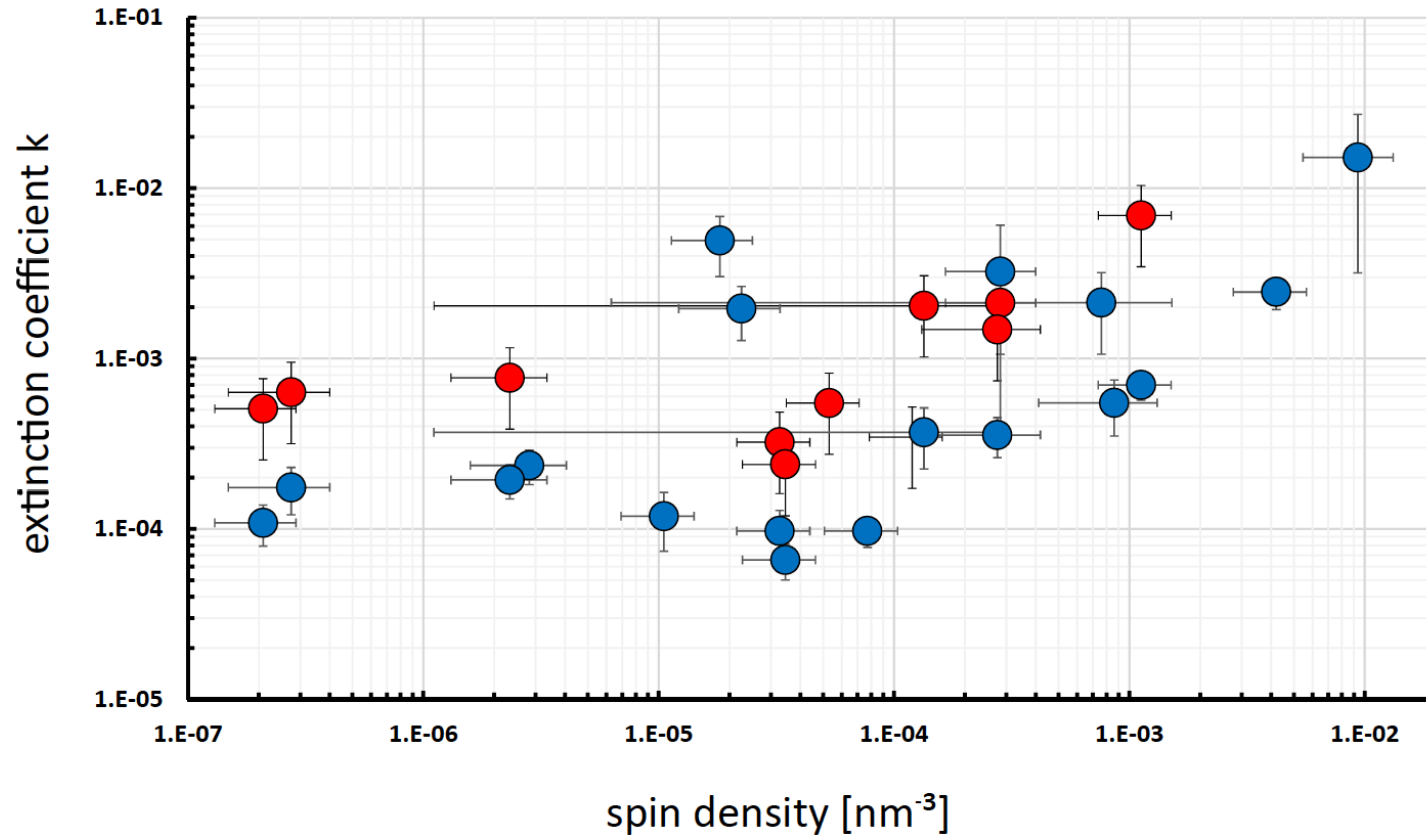
Characterisation – EPR



Electron paramagnetic resonance

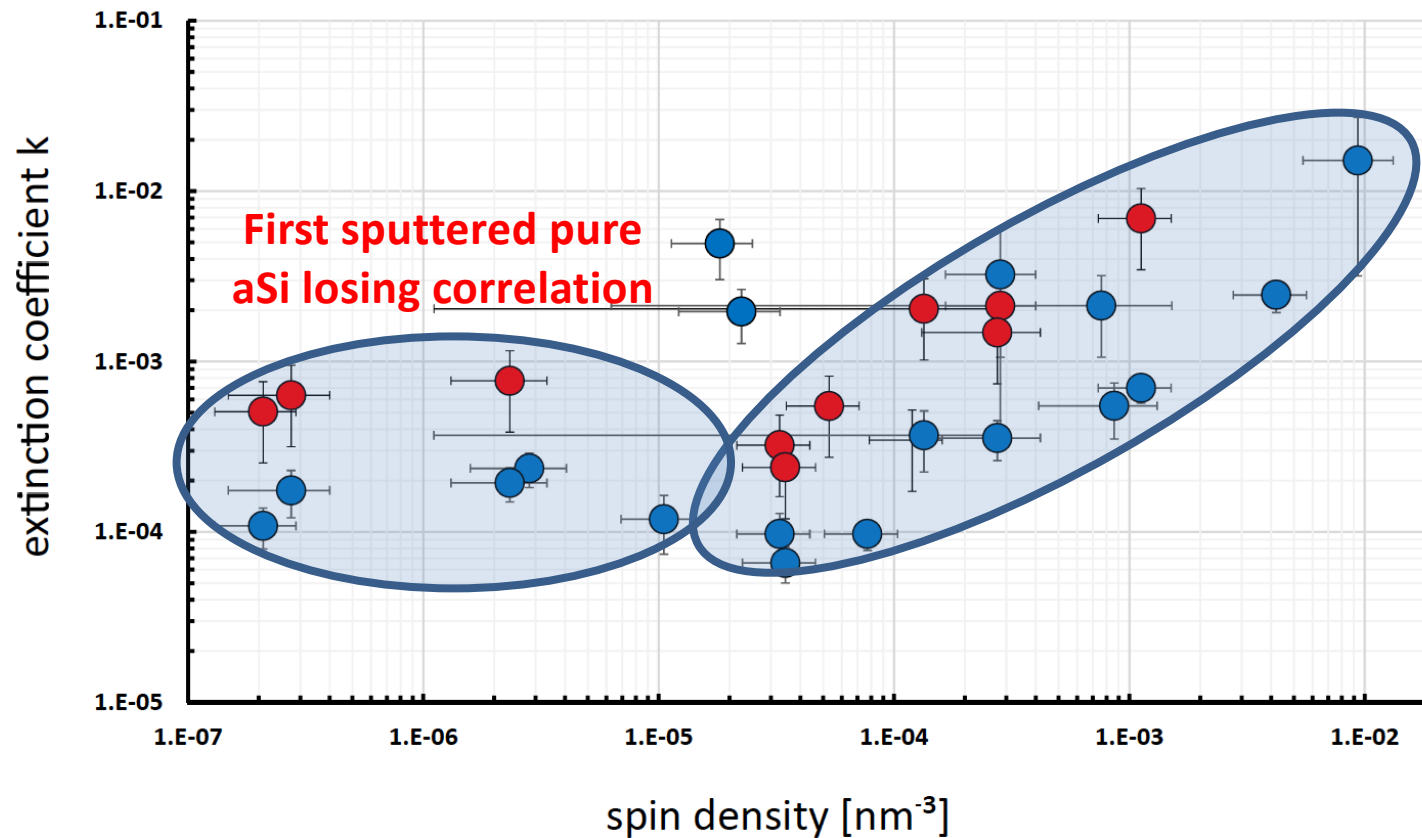
Dangling bond correlation with absorption

BLUE: 1550 nm RED: 1064



Dangling bond correlation with absorption

BLUE: 1550 nm RED: 1064



Dangling bond correlation with absorption

PHYSICAL REVIEW LETTERS **121**, 191101 (2018)

Amorphous Silicon with Extremely Low Absorption: Beating Thermal Noise in Gravitational Astronomy

R. Birney,^{1,2,*} J. Steinlechner,^{3,4,†} Z. Tornasi,³ S. MacFoy,^{1,2} D. Vine,² A. S. Bell,³ D. Gibson,² J. Hough,³ S. Rowan,³ P. Sortais,⁵ S. Sproules,⁶ S. Tait,³ I. W. Martin,³ and S. Reid^{1,2}

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²*SUPA, Institute for Thin Films, Sensors and Imaging, University of the West of Scotland, Paisley PA1 2BE, United Kingdom*

³*SUPA, Institute for Gravitational Research, University of Glasgow, Glasgow G12 8QQ, United Kingdom*

⁴*Institut für Laserphysik und Zentrum für Optische Quantentechnologien, Universität Hamburg, Luruper Chaussee 149, 22761 Hamburg, Germany*

⁵*Polygon Physics, 30 Chemin de Rochasson, 38240 Meylan, France*

⁶*WestCHEM, School of Chemistry, University of Glasgow, Glasgow G12 8QQ, United Kingdom*

 (Received 9 July 2018; revised manuscript received 23 August 2018; published 6 November 2018)

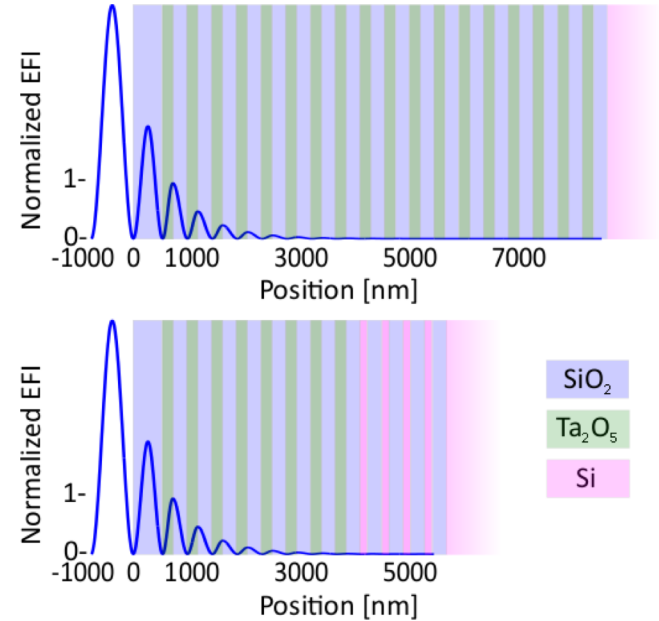
Amorphous silicon has ideal properties for many applications in fundamental research and industry. However, the optical absorption is often unacceptably high, particularly for gravitational-wave detection. We report a novel ion-beam deposition method for fabricating amorphous silicon with unprecedentedly low unpaired electron-spin density and optical absorption, the spin limit on absorption being surpassed for the first time. At low unpaired electron density, the absorption is no longer correlated with electron spins, but with the electronic mobility gap. Compared to standard ion-beam deposition, the absorption at 1550 nm is lower by a factor of ≈ 100 . This breakthrough shows that amorphous silicon could be exploited as an extreme performance optical coating in near-infrared applications, and it represents an important proof of concept for future gravitational-wave detectors.

DOI: [10.1103/PhysRevLett.121.191101](https://doi.org/10.1103/PhysRevLett.121.191101)

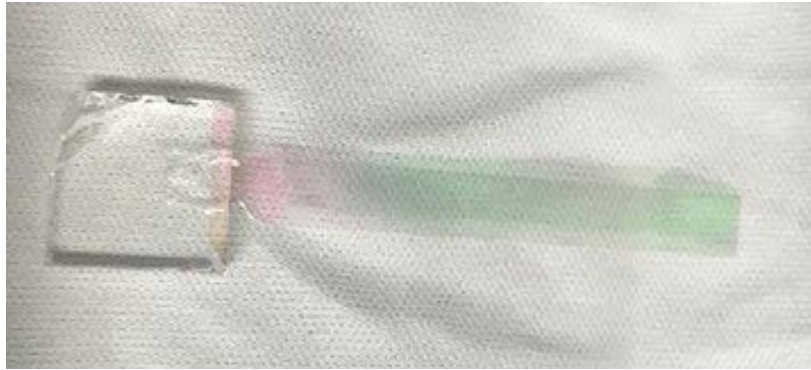
Thermal noise

Thermal noise ^a [%]	Absorption (ppm)	No. of bilayers Ti:Ta ₂ O ₅ /SiO ₂	ETM (ITM) <i>a</i> -Si/SiO ₂
Baseline	Advanced LIGO (a)		
100	≈0.3 (0.2) [41]	18.5 (9.5)	0 (0)
<i>a</i> -Si/SiO ₂	1550 nm (b)		
29.9	7.6	...	7.5 (4.5)
Multimaterial	1550 nm (c)		
49.5	2.1 (2.0)	2 (2)	6.5 (2.5)

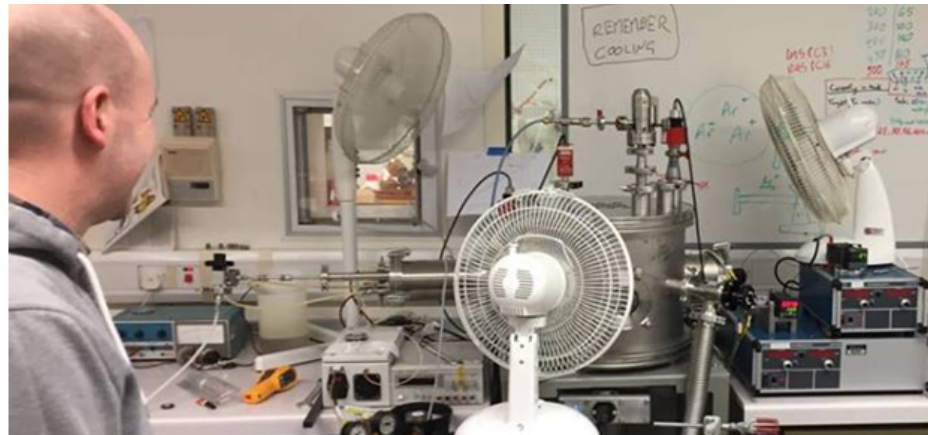
^aFor whole detector



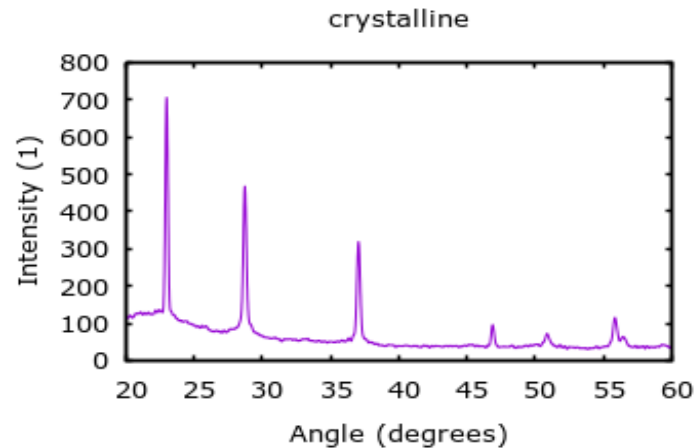
High temp deposition of tantala (Ta_2O_5)



Deposition temperatures up to 500C with some “effort”



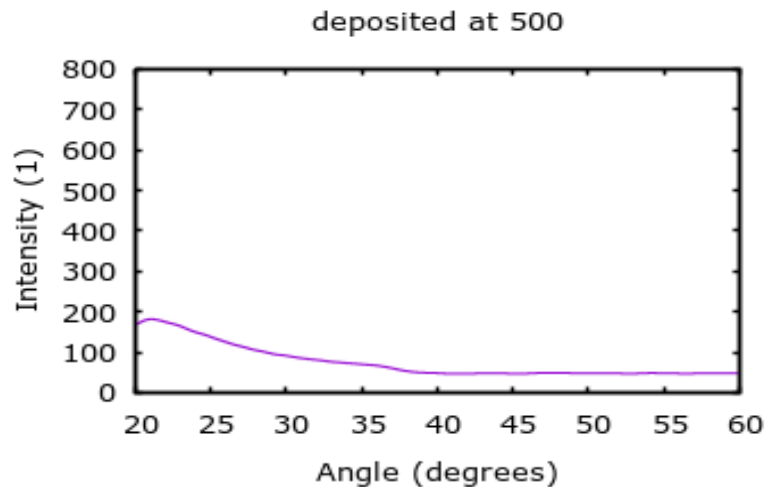
Tantala XRD



Sample of tantala deposited at 300C

Annealed at 700C for 5 hours.

Crystalline features shown



Sample of tantala deposited at 500C

Not annealed yet

Shows no crystalline features

Tantala Mechanical Loss

IOP Publishing

Classical and Quantum Gravity

Class. Quantum Grav. 35 (2018) 075001 (18pp)

<https://doi.org/10.1088/1361-6382/aaad7c>

Effect of elevated substrate temperature deposition on the mechanical losses in tantala thin film coatings

G Vajente¹, R Birney^{2,3}, A Ananyeva¹, S Angelova^{2,3}, R Asselin⁷, B Baloukas⁴, R Bassiri⁵, G Billingsley¹, M M Fejer⁵, D Gibson³, L J Godbout⁷, E Gustafson¹, A Heptonstall¹, J Hough⁸, S MacFoy^{2,3}, A Markosyan⁵, I W Martin⁸, L Martinu¹, P G Murray⁸, S Penn⁶, S Roorda⁷, S Rowan⁸, F Schiettekatte⁷, R Shink⁷, C Torrie¹, D Vine³, S Reid^{2,3} and R X Adhikari¹

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³ SUPA, Institute of Thin Films, Sensors and Imaging,

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⁴ École Polytechnique de Montréal, Montréal, Quebec, Canada

⁵ Stanford University, Stanford, CA, United States of America

⁶ Hobart and William Smith Colleges, Geneva, NY, United States of America

⁷ Université de Montréal, Montréal, Quebec, Canada

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Received 10 November 2017, revised 2 February 2018

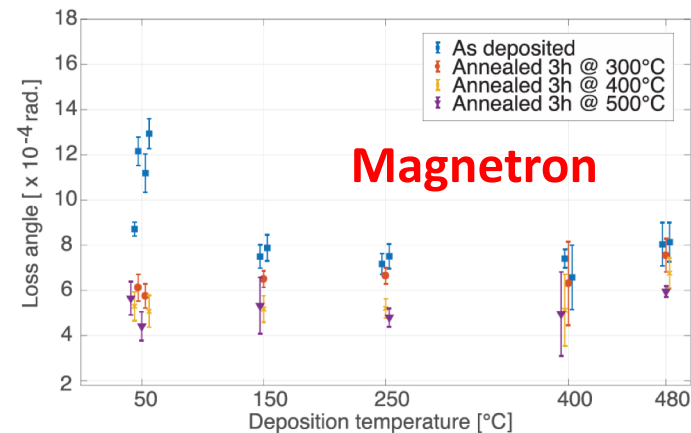
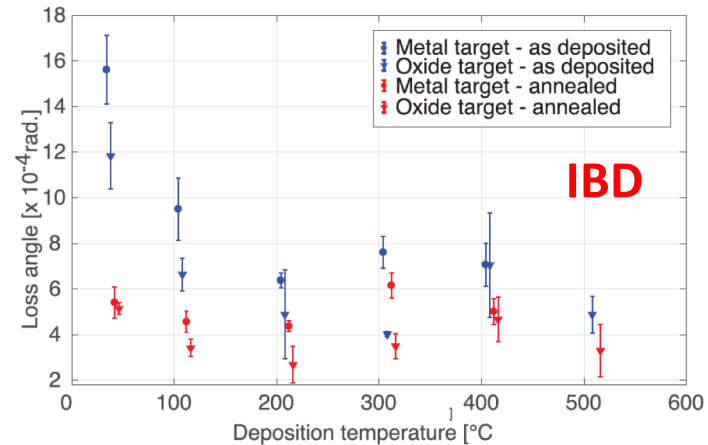
Accepted for publication 7 February 2018

Published 23 February 2018



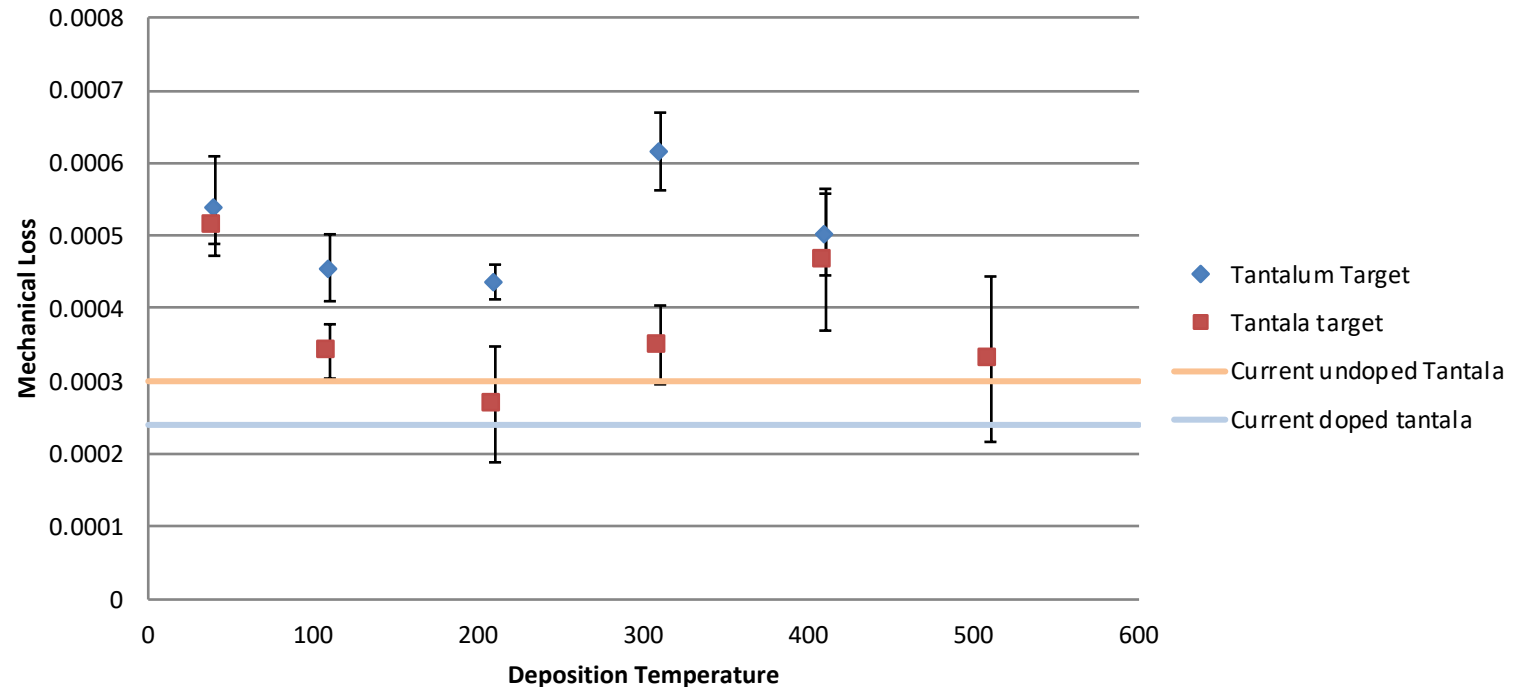
Abstract

Brownian thermal noise in dielectric multilayer coatings limits the sensitivity of current and future interferometric gravitational wave detectors. In this work



Tantala Mechanical Loss

Average of annealed coating

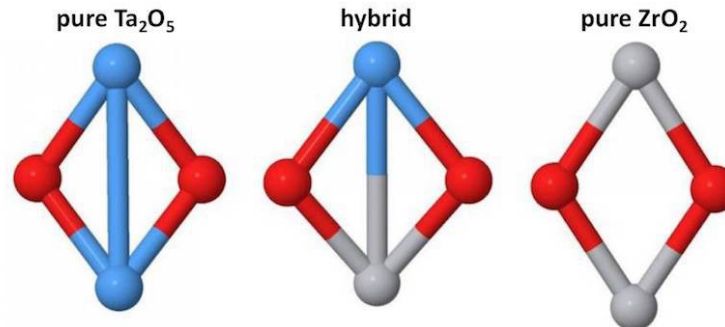


Lowest Average loss – 2.6×10^{-4} **undoped** tantalum

Increase in loss after 200 due to deposition parameters? Stoichiometry? or real effect?

Zr:Ta₂O₅ coatings - motivation

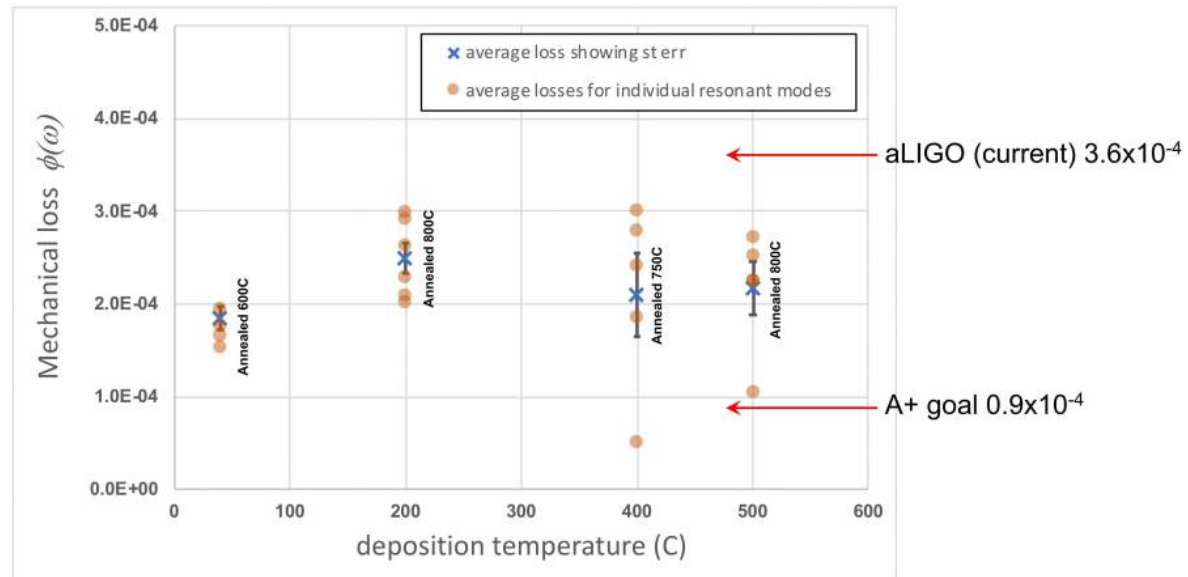
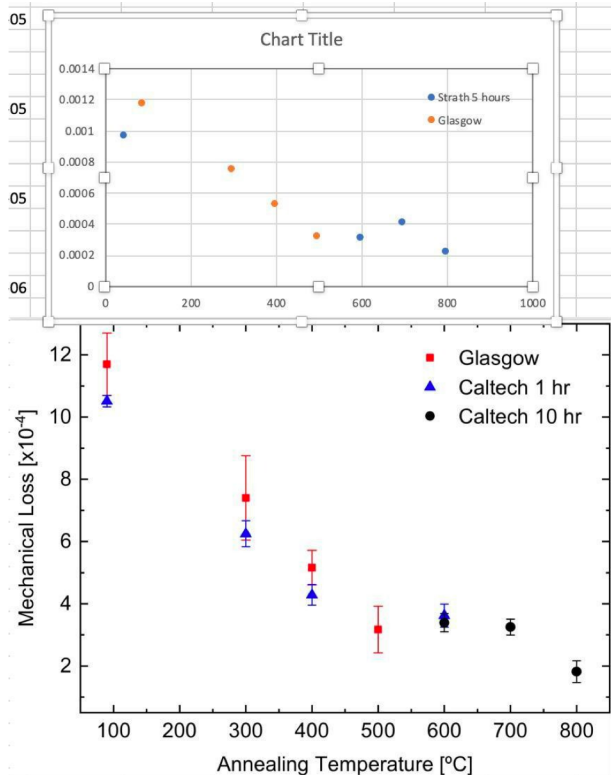
- Atomic simulation work carried out at the University of Glasgow (Glasgow group and particularly K. Evans, R. Bassiri, and K. Borisenko (Oxford)) predicted that alternative metal species, such as zirconium, could alter the dynamical behaviour of the hybrid fragments shown below and thus further reduce the mechanical dissipation.
- Marty Fejer (Stanford) and Steve Penn (HWS) also identified zirconium as a stabilising alloy which could be used to increase the crystallisation temperature, and thus provide routes to subject mirror coatings to higher heat treatment temperatures (typically higher heat treatments reduce the mechanical dissipation, however titania-tantala alloys will typically crystallise by 700C).



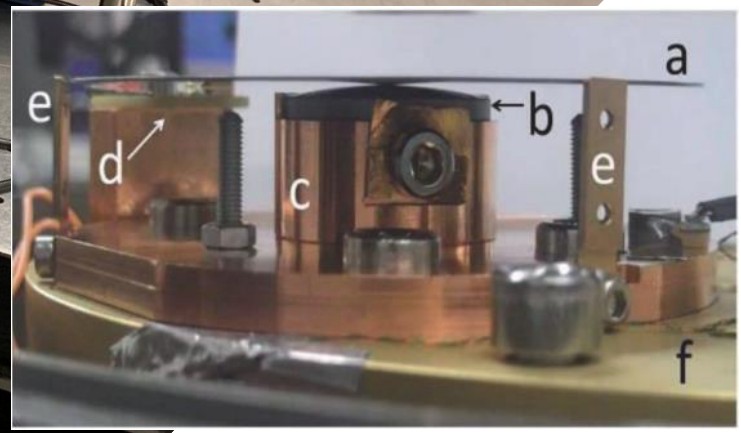
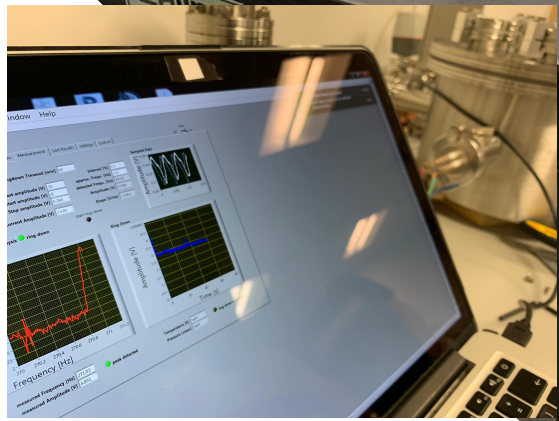
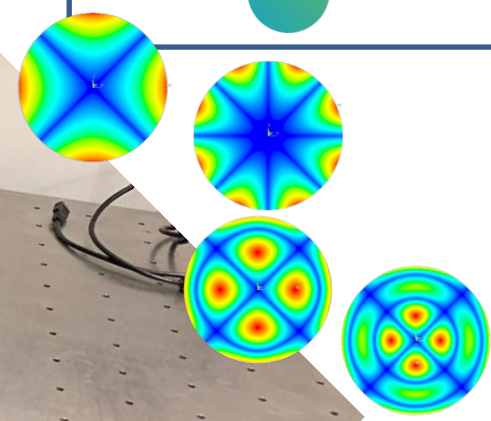
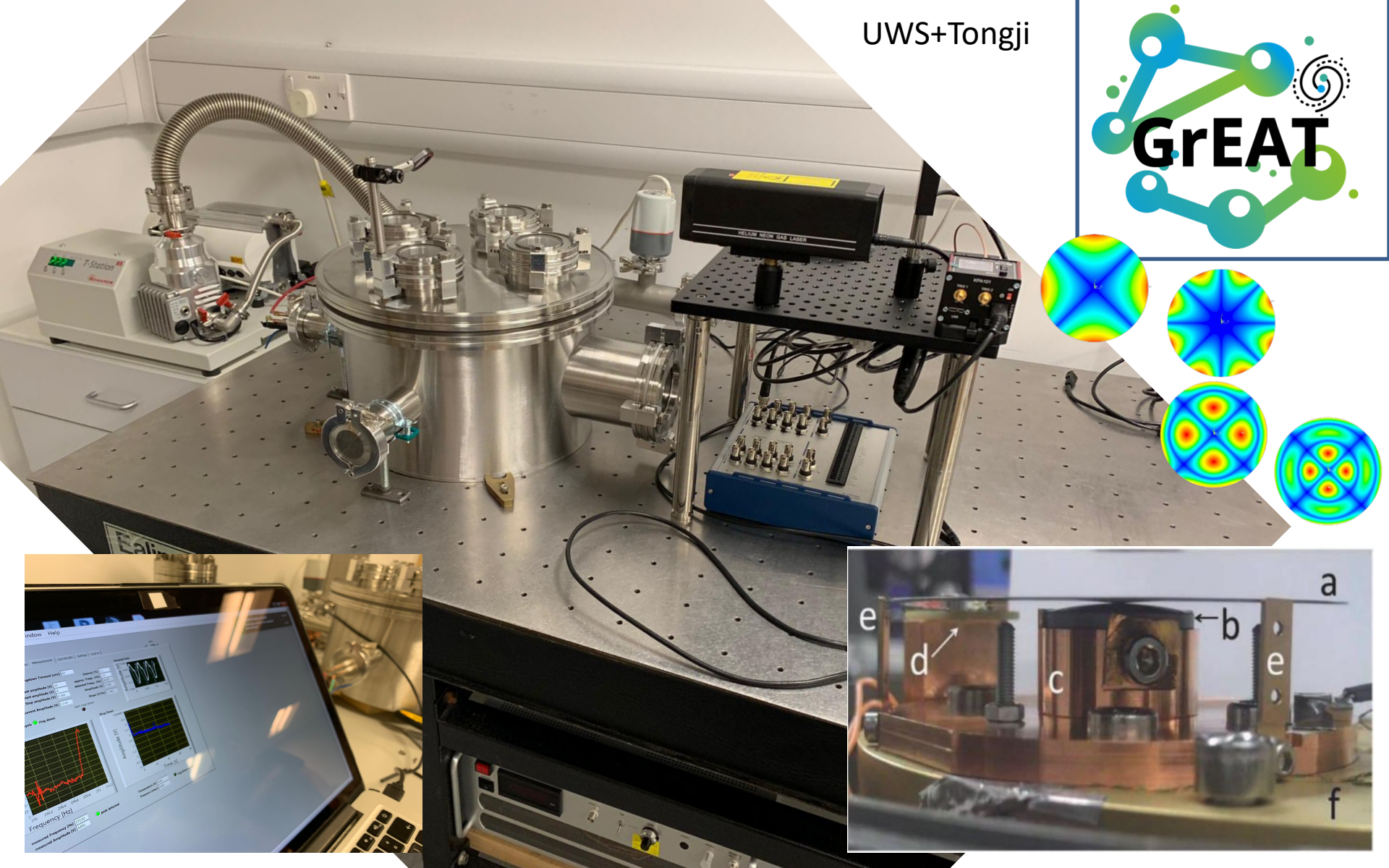
variants of the 4 atom planar fragments found in Ta₂O₅ and ZrO₂:Ta₂O₅ models.

Zr:Ta₂O₅ coatings - mechanical loss

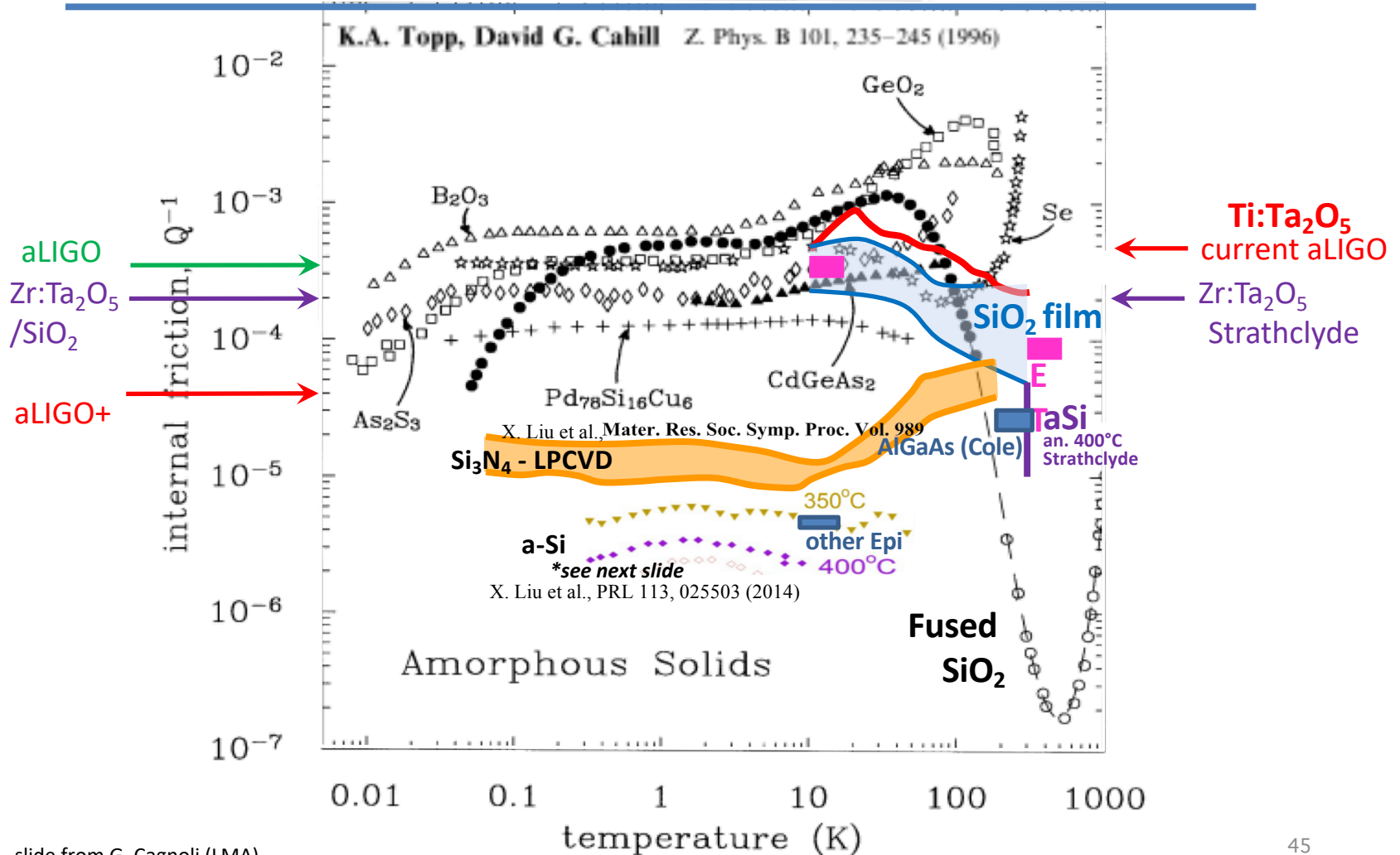
- Coatings produced by Strathclyde group, using a new IBS technique, show losses **around 2x lower than measured in Ti:Ta₂O₅ used in aLIGO**
 - Following predictions of (a) structural modelling and (b) increase of crystallisation temperature, allowing higher temperature annealing to reduce loss
 - Very promising for reducing coating thermal noise for A+



UWS+Tongji



Summary

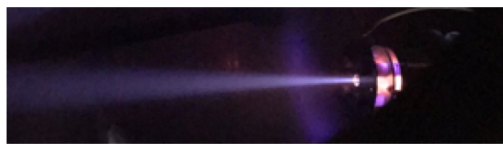


Conclusions

- Significant effort being invested by UK groups to design, fabricate and characterise optical coatings relevant to future and 3G GW detectors.
- aSi coatings highly attractive solution – but in mixed material design + 1550 nm
- Zr:Ta₂O₅ shows repeatable loss at the level $\phi = 2.0 \times 10^{-4}$ (40% reduction c.f. Ti:Ta₂O₅).
- Direct side-by-side comparison of ECR-IBD and RF-IBD coatings in "same" lab in 2019.
- Successful MBE growths of GaP on silicon → development/optimisation of GaP/AlGaP.
- *We thank the LSC, Virgo, KAGRA and ET communities for support and encouragement!*



Questions?



- Ta₂O₅ – recheck ultimate ϕ on pure tantalum (ECR) – new system + uniform + GeNS
- ZrO₂:Ta₂O₅ – as above
- TiO₂:Ta₂O₅ – as above – Qn: how does Ti and Zr doping compare using ECR re ϕ .
- Ti⁺⁺ – increase Ti content and check TiO₂:ZrO₂:Ta₂O₅ -> increase n , reduce thickness

- ZrO₂ – pure zirconia for comparison

- LaTiO₃ – should have ϕ for initial tests completed soon – repeat if interesting

- V₂O₅ – vanadia to compare ϕ vs structure (Raman), since v similar structure to tantalum

- Sc₂O₃ – low absorption at 1064nm from Colorado State (Krous 2010, thesis) – check ϕ
- HfO₂ – compare ECR to RF

- aSi / SiNx – we will return to this when cryopumps are installed on systems (2019)

- Fluorides – no immediate plans, but might need to consider this later in 2019 if above materials do not look attractive enough for A+.

Low index too: SiO₂ and Al₂O₃ – both trialed in ECR system but not optimised

Target materials for above (excl. fluorides) are in lab

Processes and further collaborative work

- Priority 1: quantify benefit of ECR vs RF regarding ϕ .
(effect of dep rate, ion energy, etc)
- **UWS:** will use Microdyn system (microwave plasma assist DC magnetron sputtering) to:
 - Pure Sc_2O_3
 - Pure Ta_2O_5 at low, standard and high microwave assist power (“microwave annealing”)
 - $\text{TiO}_2:\text{Ta}_2\text{O}_5$ (aim for 15% TiO_2 in Ta_2O_5)
 - $\text{ZrO}_2:\text{Ta}_2\text{O}_5$ (aim for 15% ZrO_2 in Ta_2O_5)
- **Strath+UWS:** Install plasma assist source from UWS in IBD systems in Strathclyde (oxygen = standard, but will investigate He “tickling” as alternative to elevated temperature dep)
- New grant with commercial partner (Gooch and Housego) to investigate scale-up of the ECR process.
- Production of multilayer coatings for further characterisation (+ direct TN!).